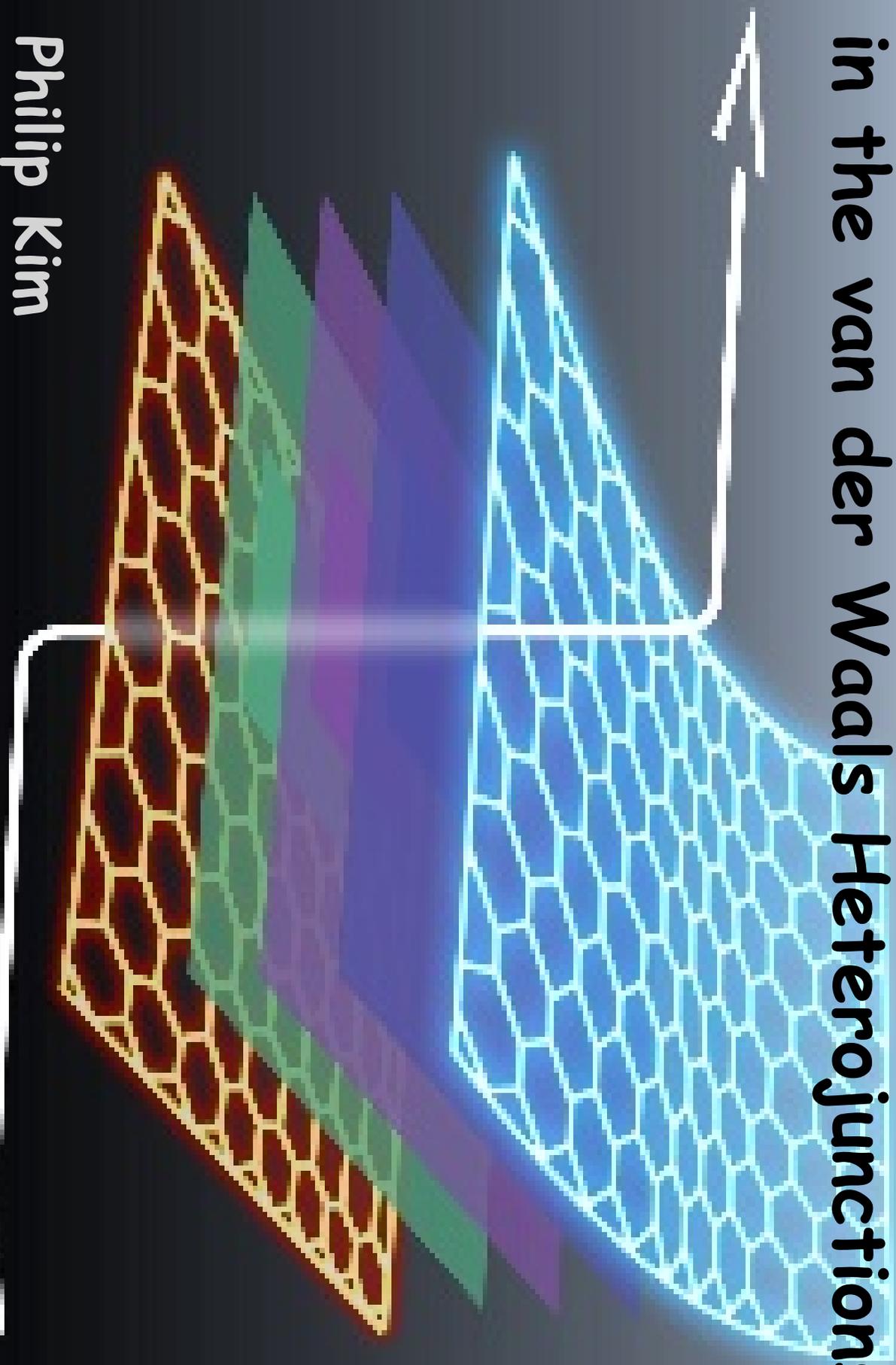


# Electronic and Optoelectronic Physics in the van der Waals Heterojunctions

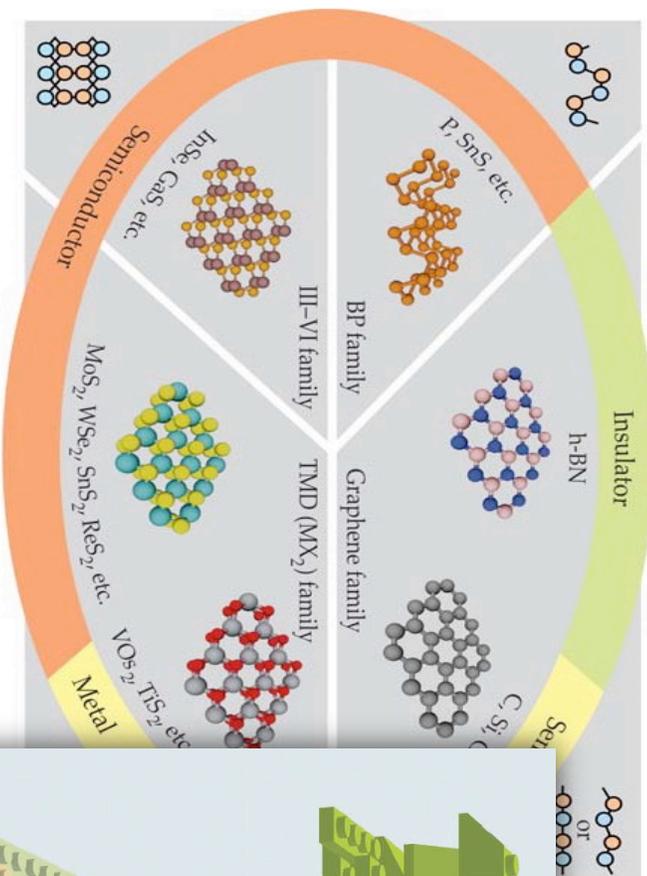


Phillip Kim

Physics & Applied Physics, Harvard University

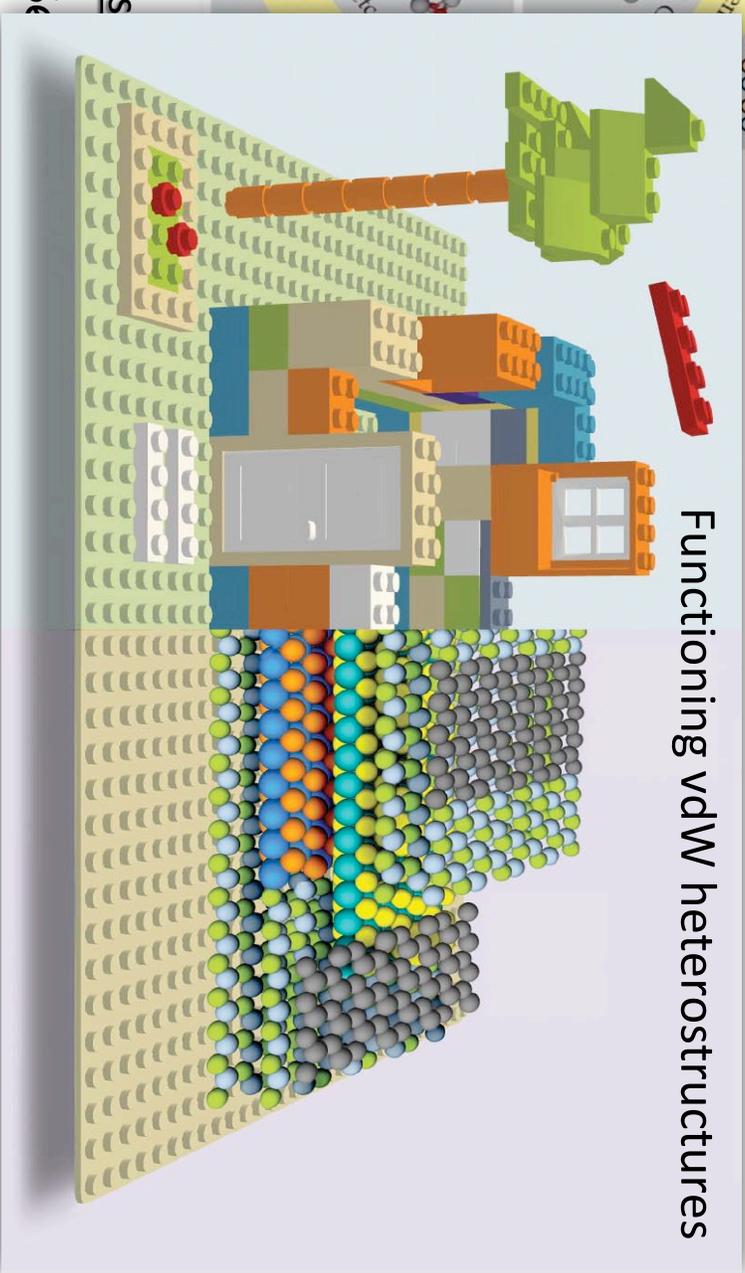
# Assembling van der Waals Materials

## 2D van der Waals Materials Family

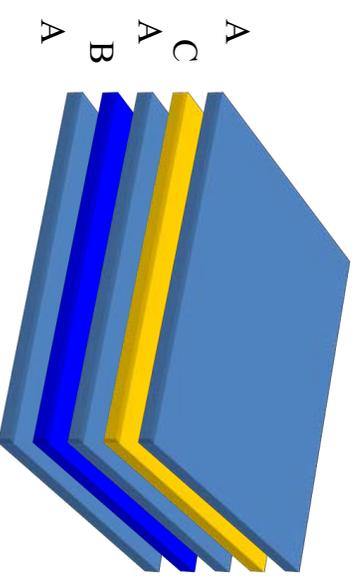


## Experimentally popular vdW Materials

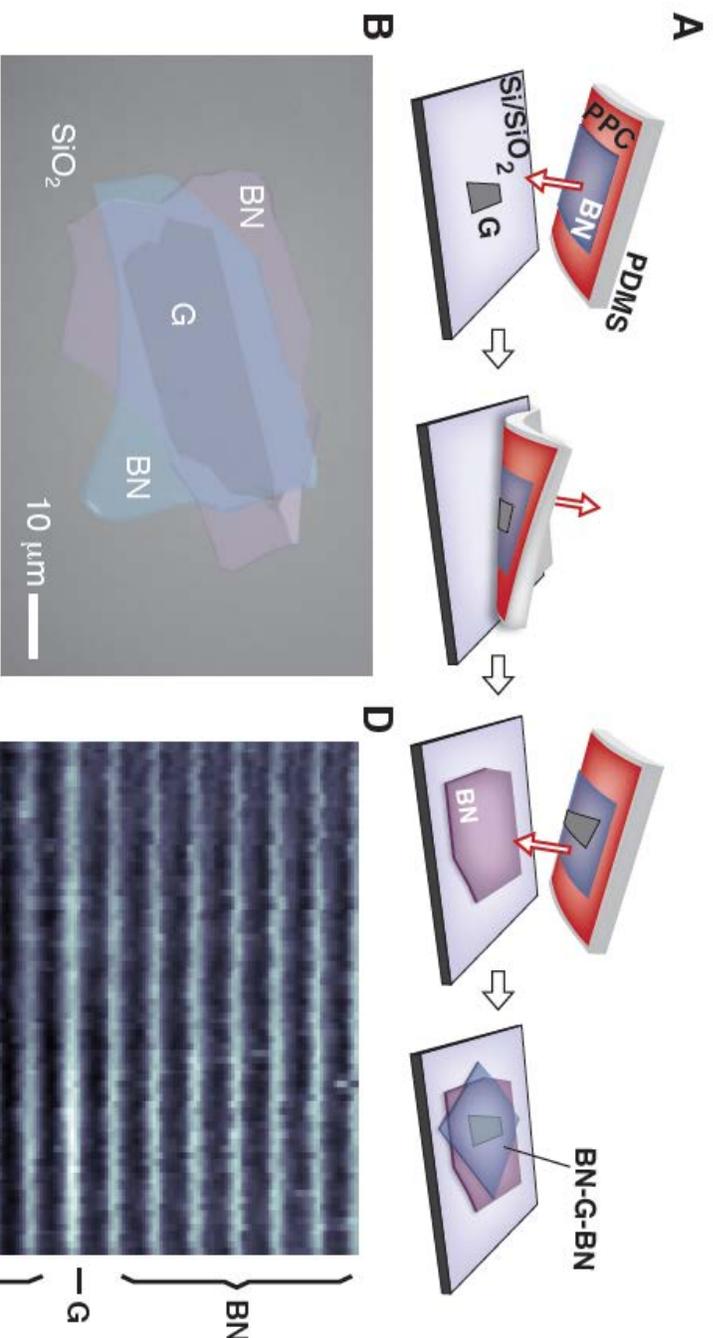
- **Semiconducting materials:** WS<sub>2</sub>, MoS<sub>2</sub>, SnS<sub>2</sub>, GaS, InSe, etc.
- **Complex-metallic compounds :** TaSe<sub>2</sub>, TaS<sub>2</sub>, ...
- **Magnetic materials:** Fe-TaS<sub>2</sub>, CrSiTe<sub>3</sub>, CrI<sub>3</sub>...
- **Superconducting:** NbSe<sub>2</sub>, Bi<sub>2</sub>Sr<sub>2</sub>CaCu<sub>2</sub>O<sub>8-x</sub>,...
- **Topological Insulator/Wyle SM:** Bi<sub>2</sub>Se<sub>3</sub>, MoTe<sub>2</sub>



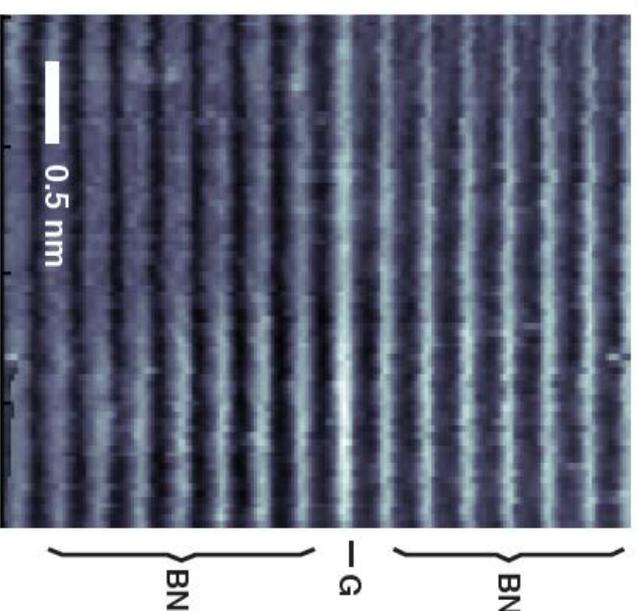
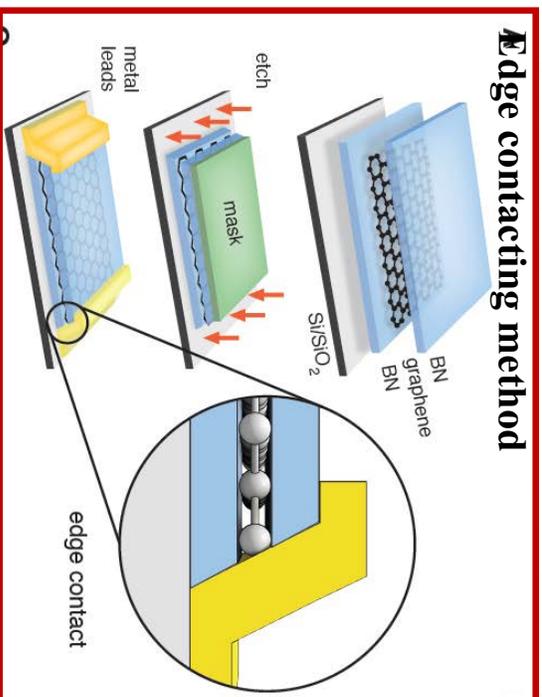
Ajayan, Kim and Banerjee, Physics Today (2016)



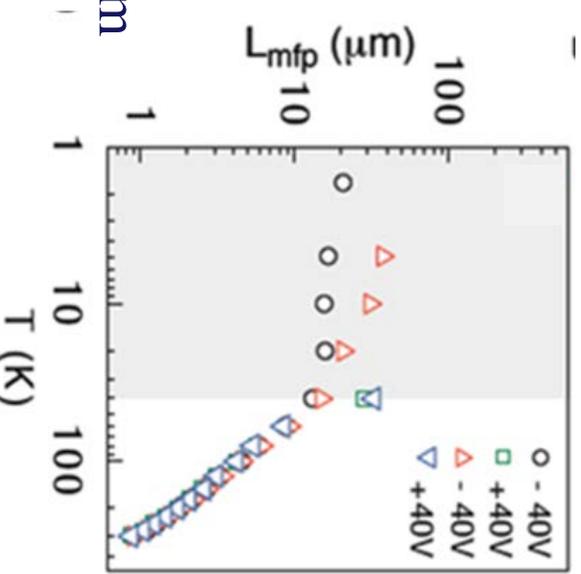
# Pick-up Technique and Edge Contacts for Multilayer vdW Stacking



- Creation of multilayer systems with co-lamination techniques
- Encapsulated graphene in hBN
- Completely ballistic at low temperature



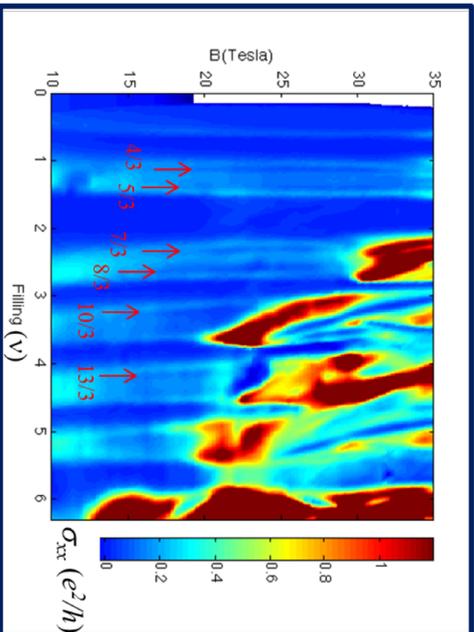
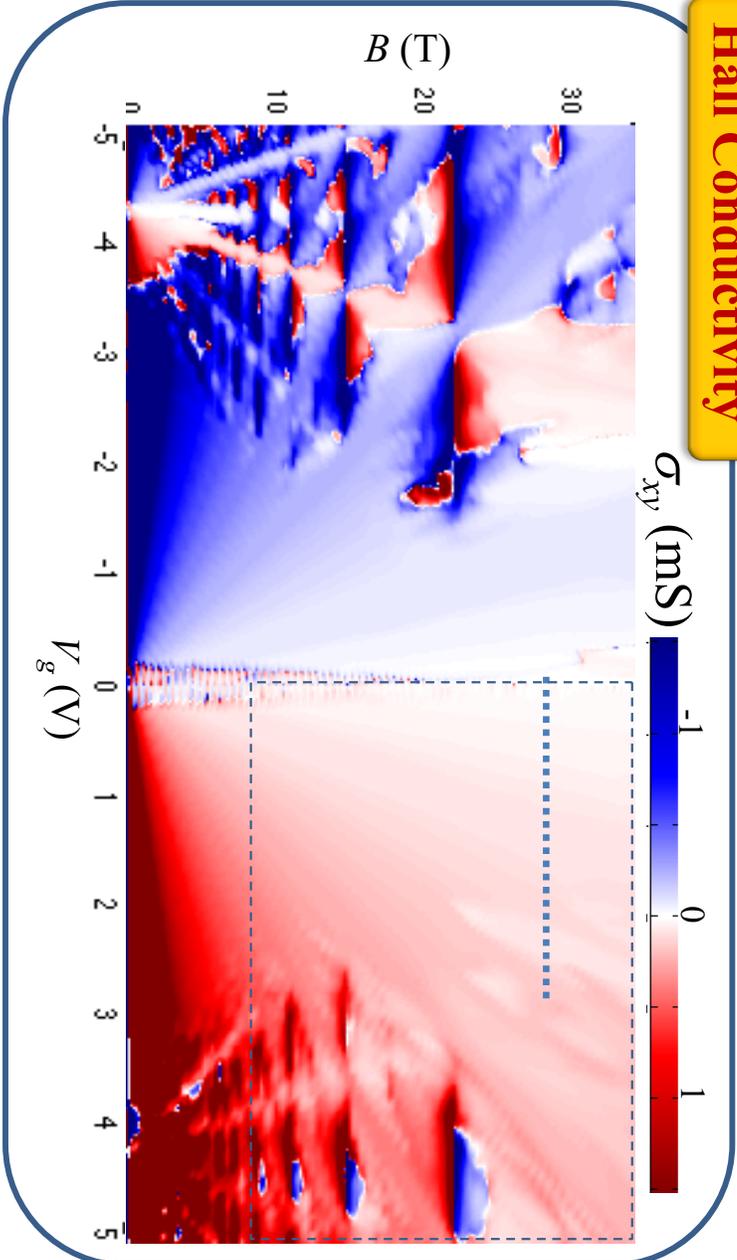
Contact Resistance:  $100 \Omega \mu\text{m}$   
 Mobility  $\sim 10^6 \text{ cm}^2/\text{Vsec}$   
 Mean free path  $> 10 \mu\text{m}$



# Fractional and Fractal Quantum Hall Effect

Single layer graphene on hBN @ 20 mK up to 35 T

Hall Conductivity

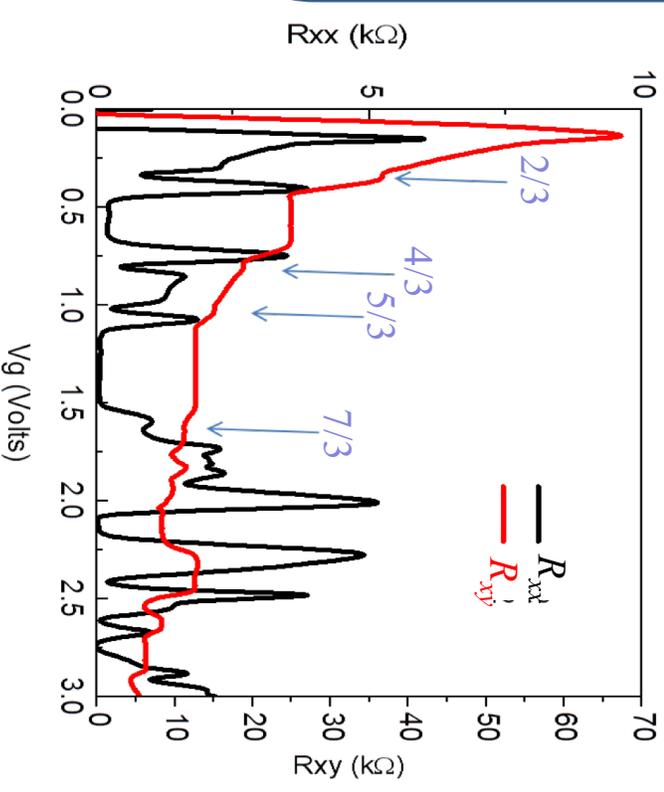


- Coexistence of Fractional Quantum Hall effect and Fractal Quantum Hall Effect.
- Can we observe Fractional Fractal Quantum Hall Effect?



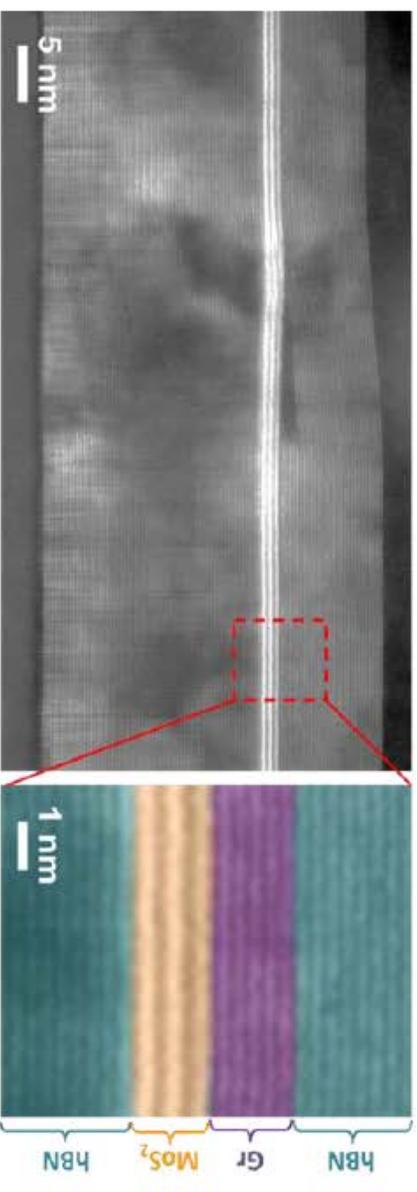
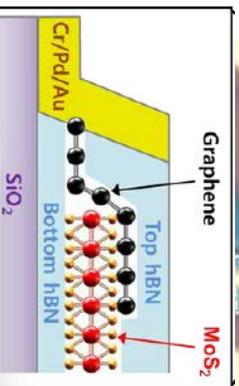
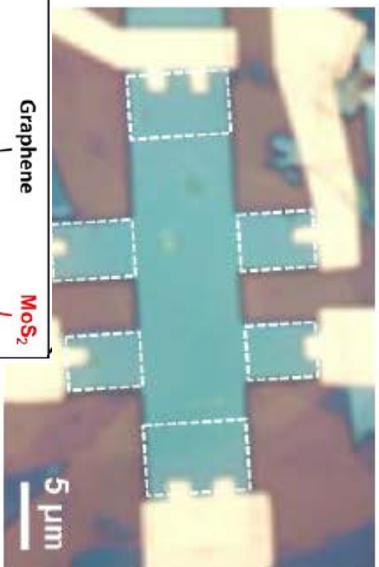
Hofstadter's butterfly in moire superlattice

## Fractional Quantum Hall Effect

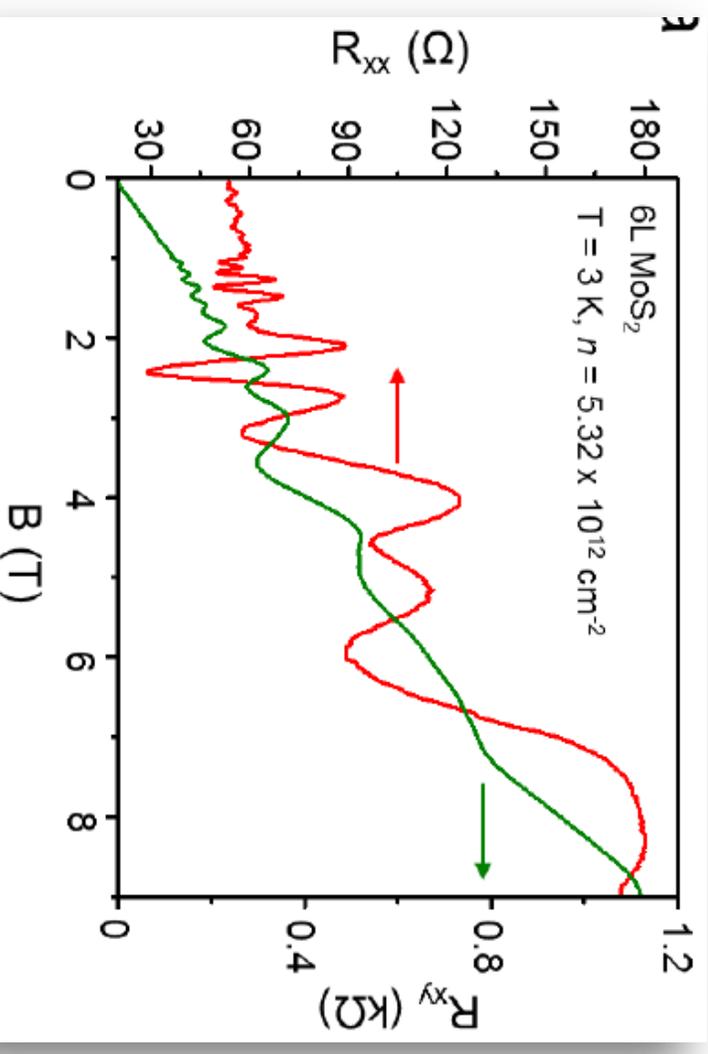
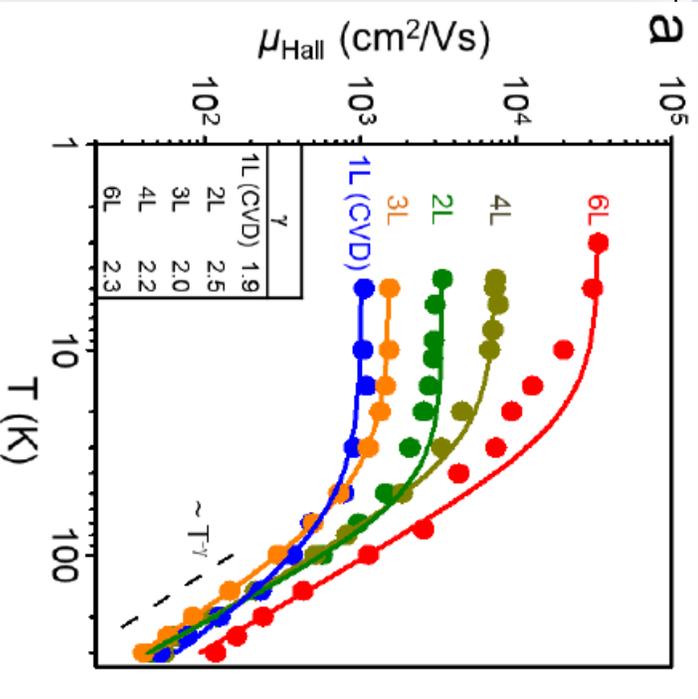


# Encapsulation of vdW semiconductors in between hBN

Xu *et al.*, Nature Nano (2015) (Hone group collaboration)

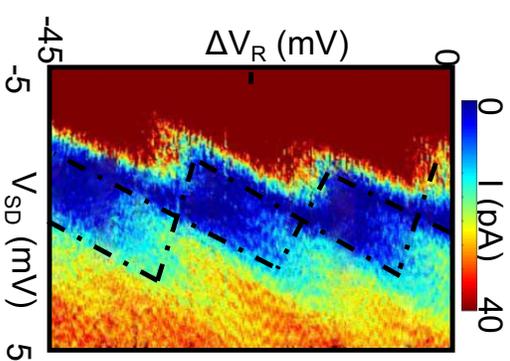
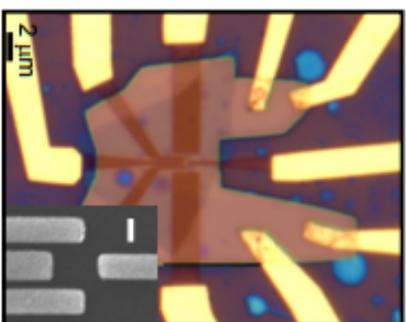
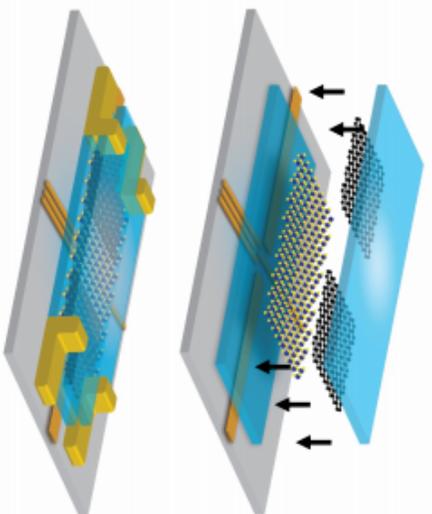


## MoS<sub>2</sub> encapsulated in hBN with graphene electrodes



# TMDC Quantum Electronic Devices

## Single Electron Transistor

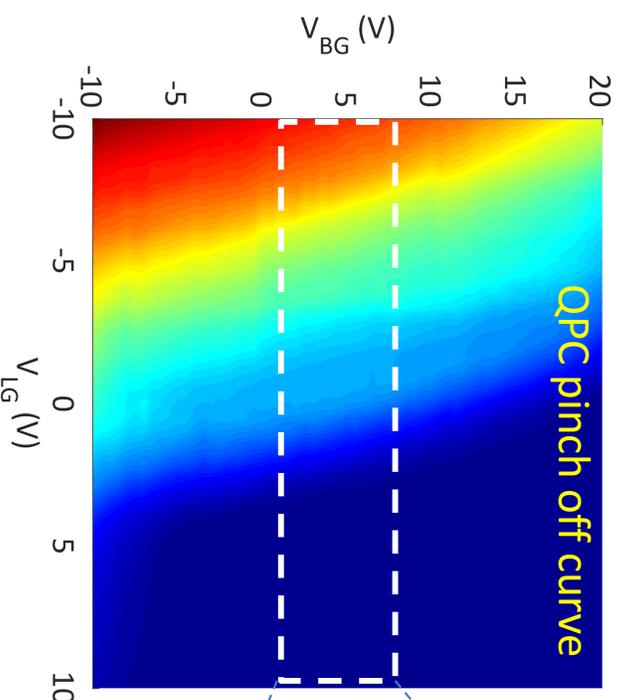
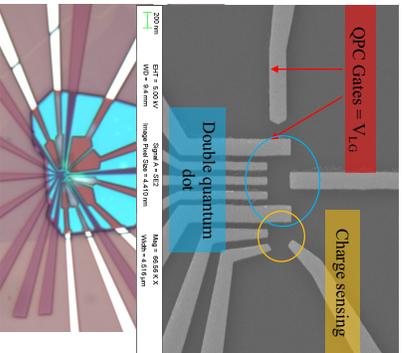


K. Wang *et al.*, Nature Nano (2018);

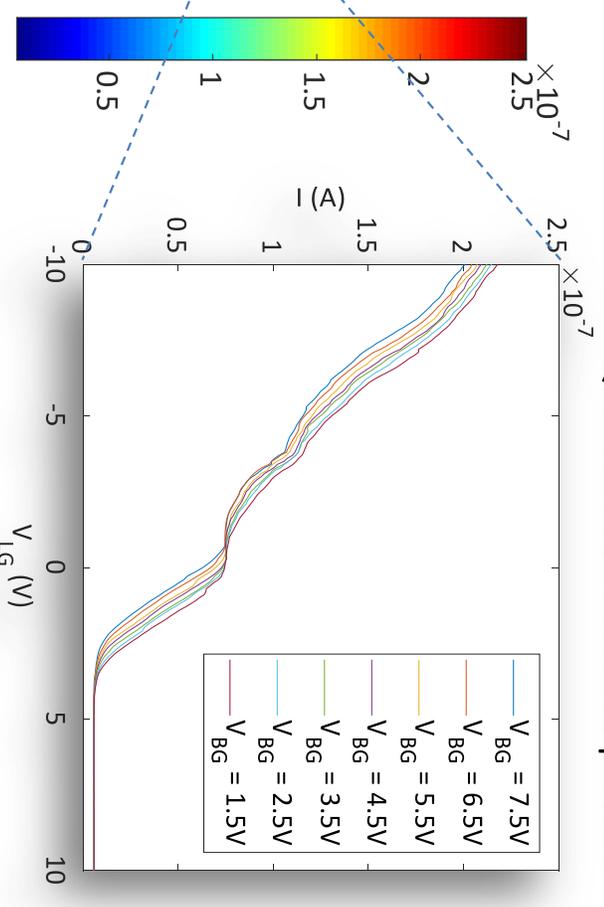
Graphene contacts  
3 layer hBN/ MoS<sub>2</sub>/hBN

## Quantum Point Contact

Double quantum dot and QPC charge sensor in hBN-WSe<sub>2</sub>-hBN heterostructures.



Current (A) across QPC

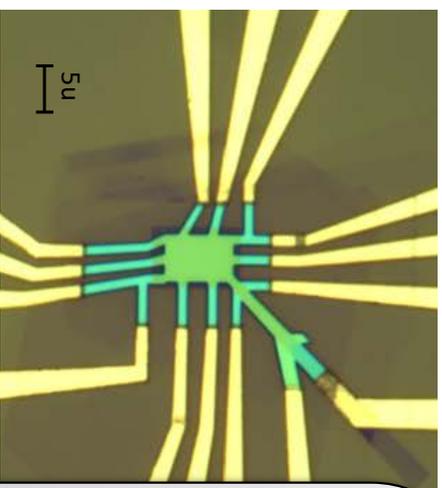
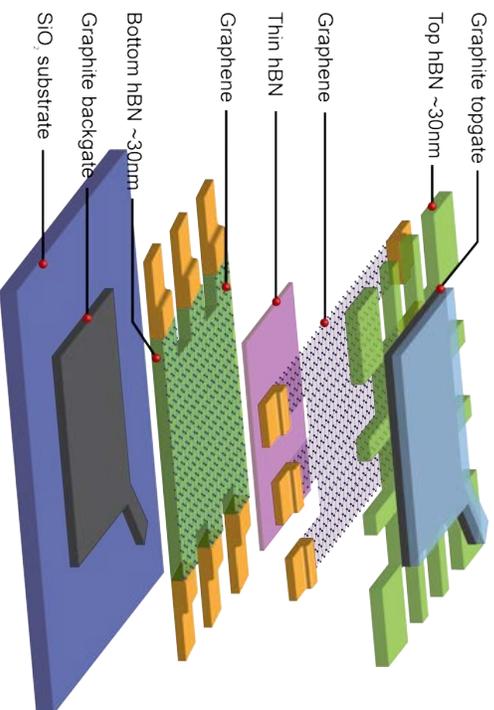


Quantum Conductance plateau

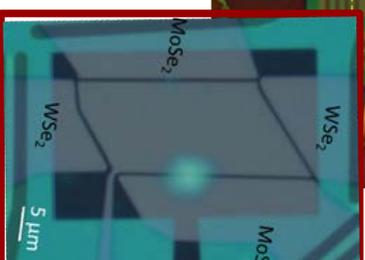
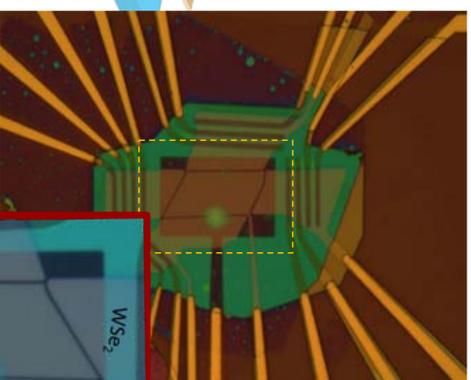
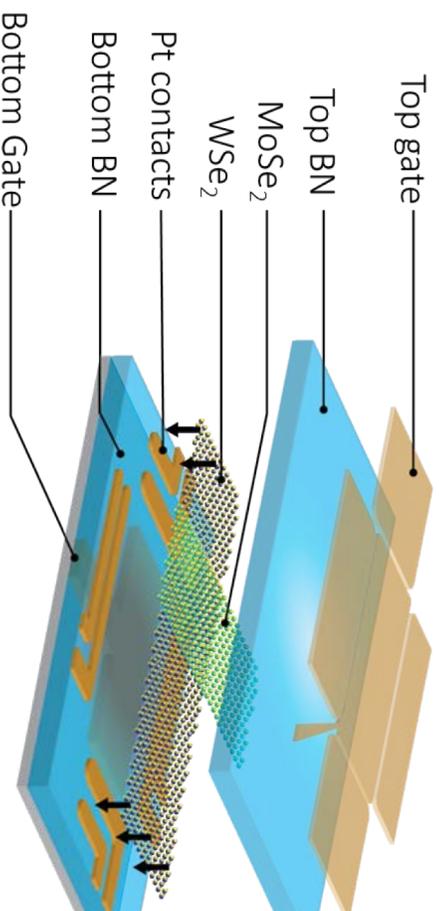
A. Joe *et al.*, unpublished (2018);

# vdW Heterostructure Devices

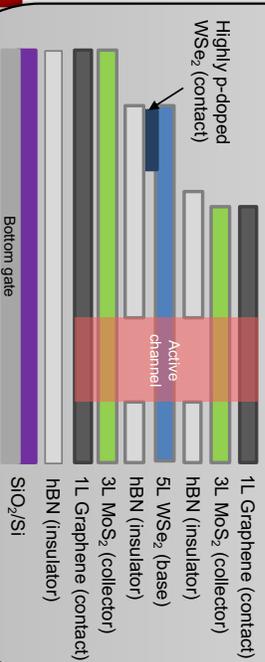
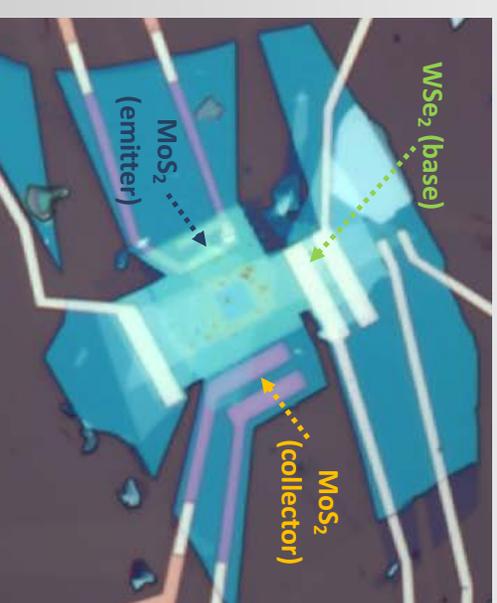
## Coulomb Drag in Graphene



## WSe<sub>2</sub>/MoSe<sub>2</sub> Optoelectronic Device

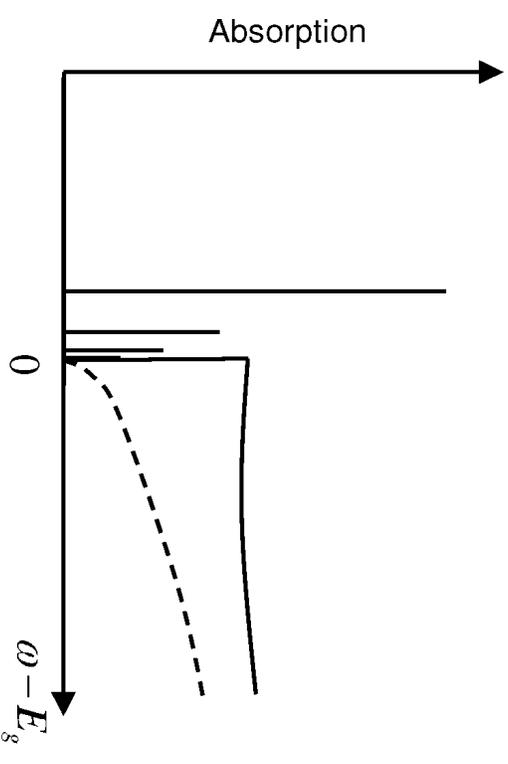
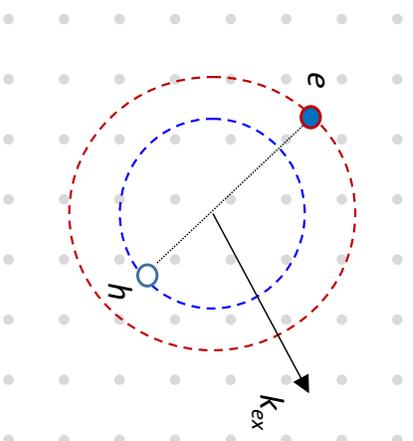
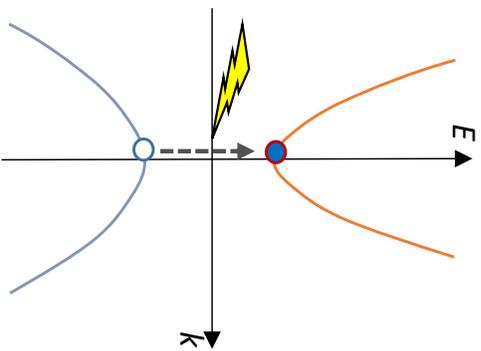


## vdW Bipolar Transistor



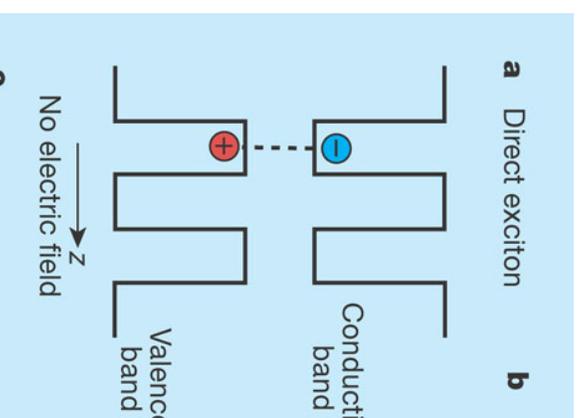
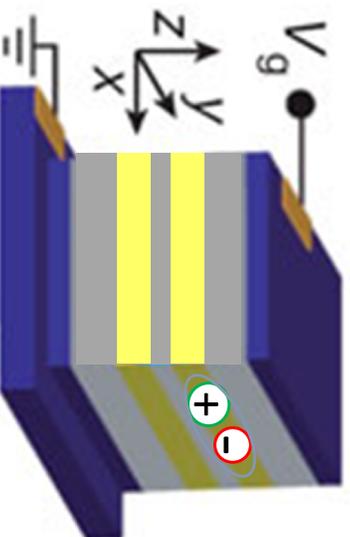
# Excitons

## Excitons in Semiconductors

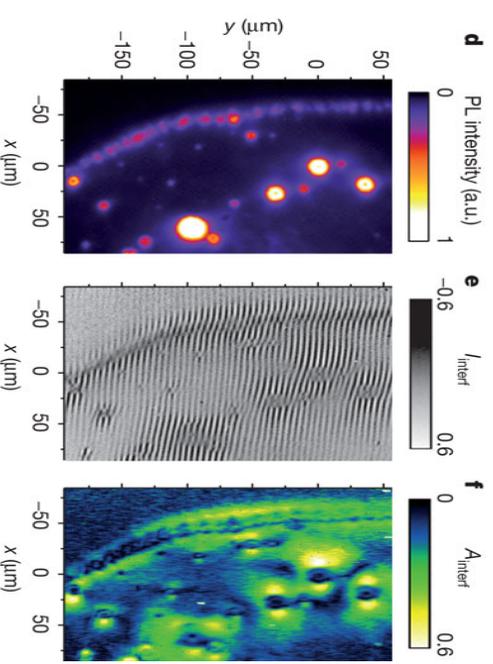


## Direct and indirect excitons in semiconducting quantum wells

Semiconductor heterostructure



Spontaneous coherence



# Excitons in 2D Materials

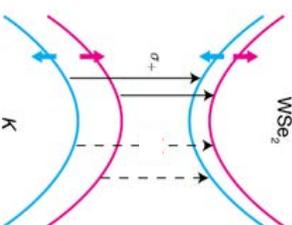
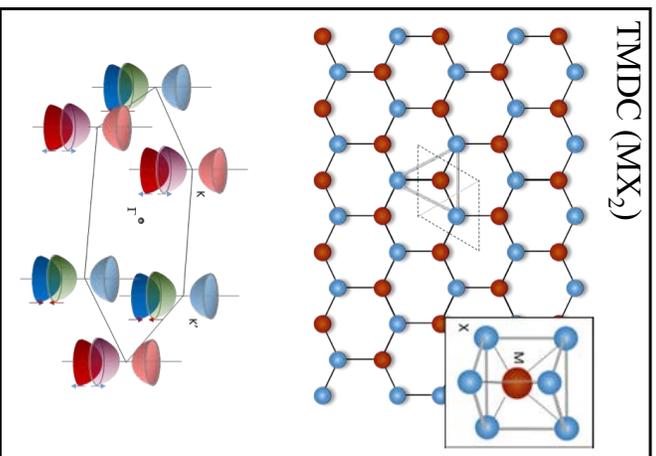
nature  
physics

LETTERS

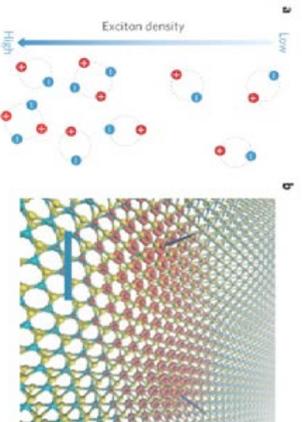
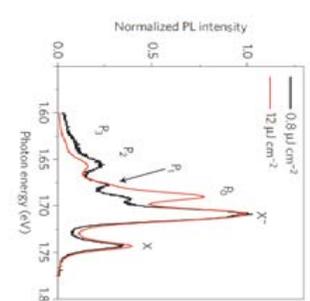
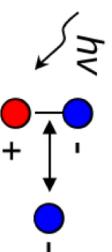
PUBLISHED ONLINE: 11 MAY 2015 | DOI: 10.1038/NPHYS3324

## Observation of biexcitons in monolayer WSe<sub>2</sub>

Yumeng You<sup>1,2†</sup>, Xiao-Xiao Zhang<sup>2†</sup>, Timothy C. Berkelbach<sup>3</sup>, Mark S. Hybertsen<sup>4</sup>, David R. Reichman<sup>3</sup> and Tony F. Heinz<sup>2,\*†</sup>



Spin-valley locking  
Strongly bound exciton & trions



- Strong confinement
- Lack of strong screening effect

- Spin polarized band
- Spin-valley locking

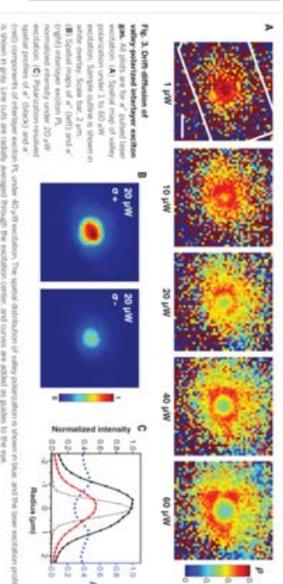
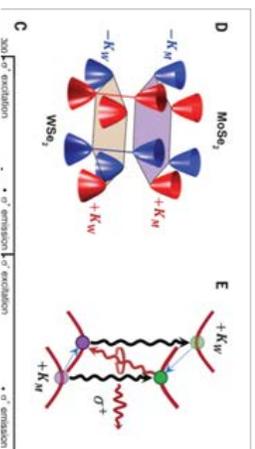
RESEARCH | REPORTS

688 12 FEBRUARY 2016 • VOL. 531 ISSUE 6274

VALLEYTRONICS

## Valley-polarized exciton dynamics in a 2D semiconductor heterostructure

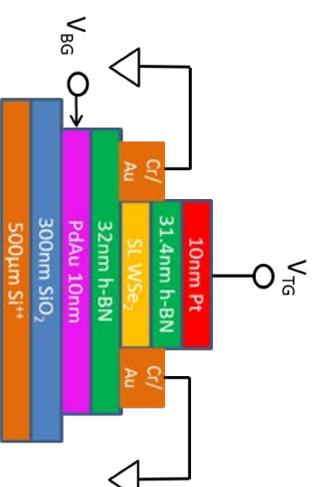
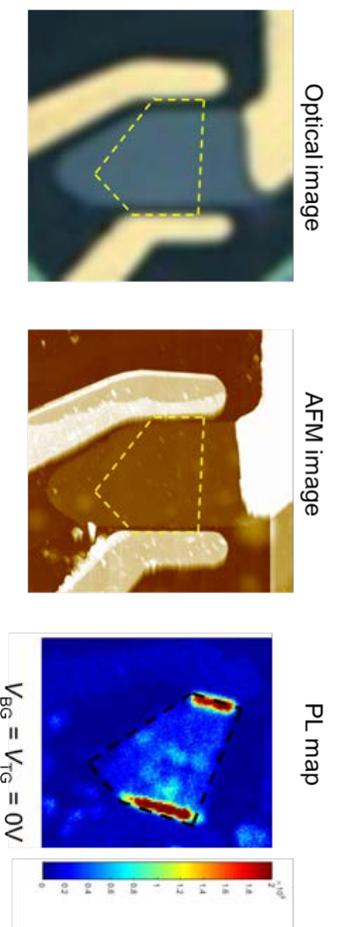
Pasqual Rivera,<sup>1</sup> Kyle L. Seyler,<sup>1</sup> Hongyi Yu,<sup>2</sup> John R. Schaibley,<sup>1</sup> Jiaqiang Yan,<sup>3,4</sup> David G. Mandrus,<sup>3,4,5</sup> Wang Yao,<sup>2</sup> Xiaodong Xu<sup>1,4,6</sup>



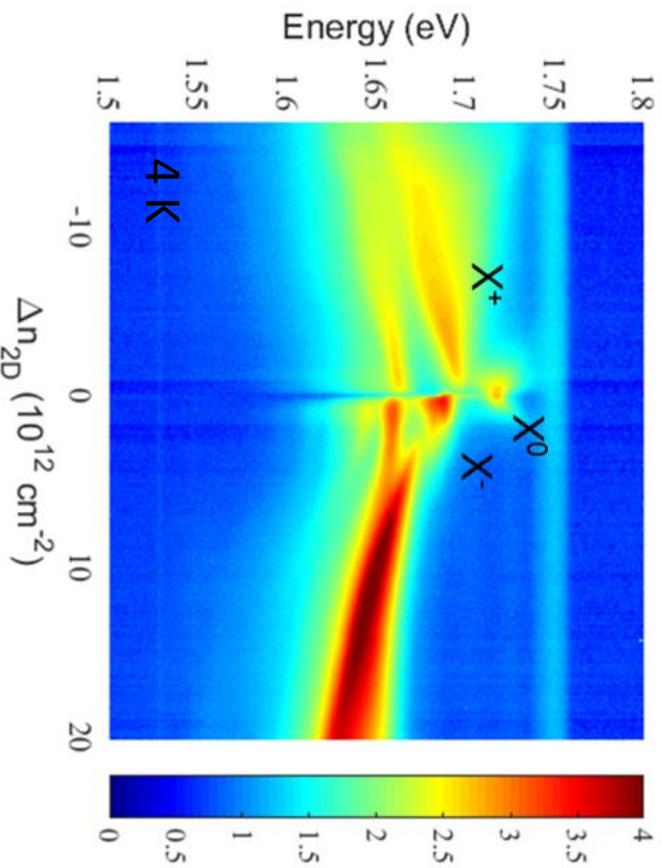
# Gate Tunable Optical Properties of WSe<sub>2</sub>

- Top and bottom gate to control electric fields and density at T = 4K
- Monolayer WSe<sub>2</sub> is grounded
- $V_{BG} = V_{TG}$ , zero E-field → **change of carrier density only**
- Thick. of bottom and top h-BN: 32nm and 31.4nm, respectively

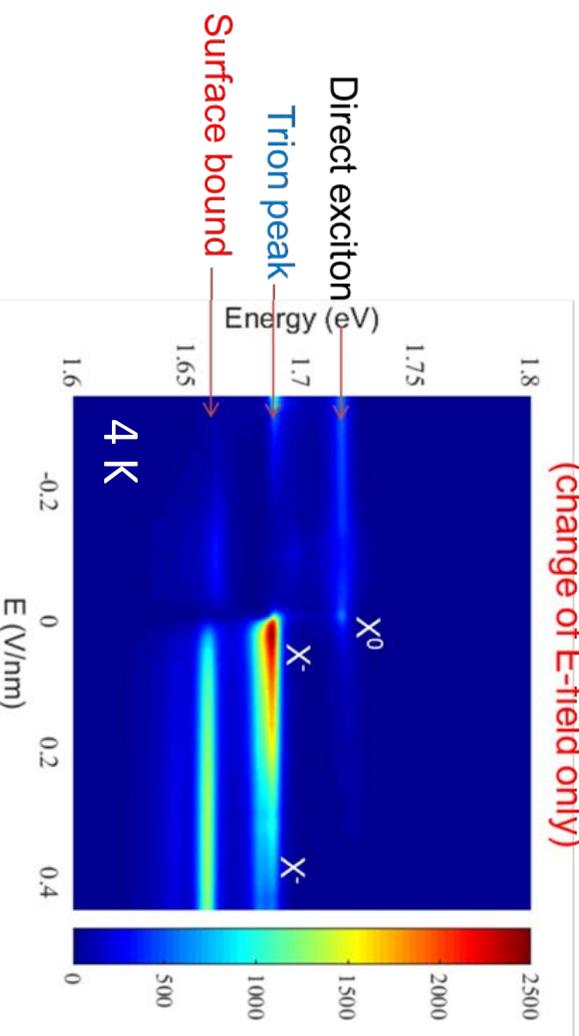
Earlier work:  
Jones *et al* (Xue), Nat. Nano (2013)



## Photoluminescence



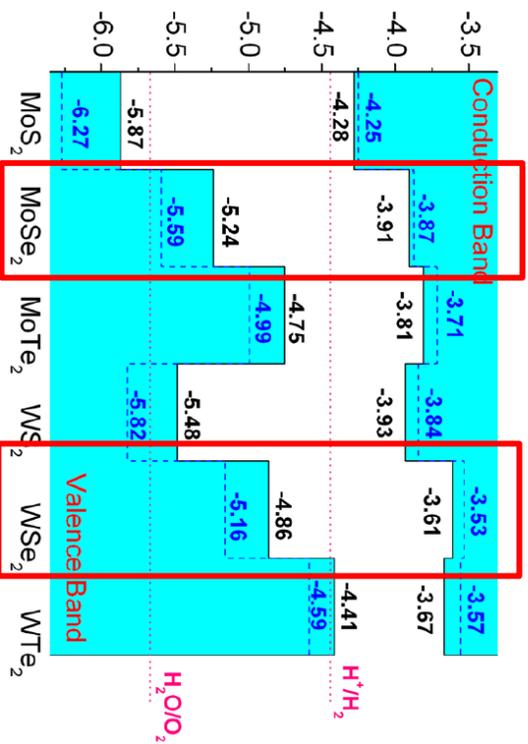
$\text{Log}_{10}(\text{Intensity})$



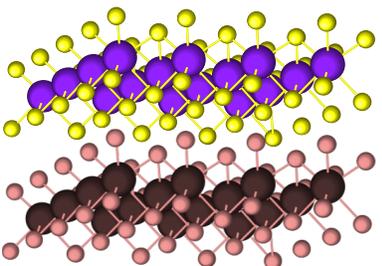
$V_{BG} = -V_{TG}$ , zero carrier density  
(change of E-field only)

# Atomically Thin vdW p-n junction

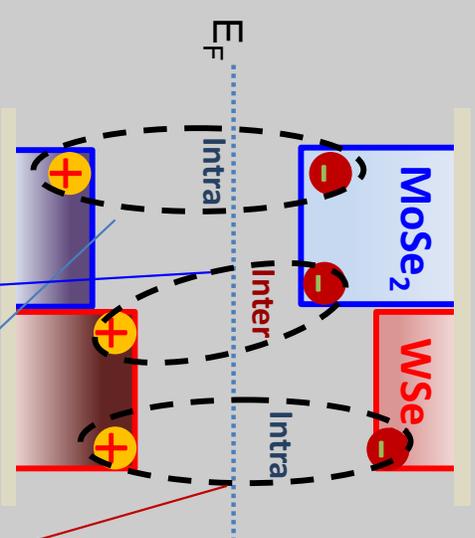
## Band gaps and alignment of vdW semiconductors



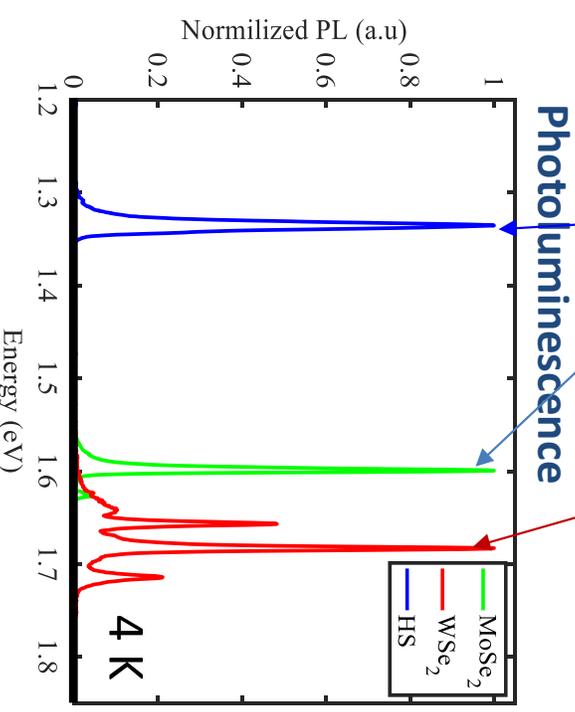
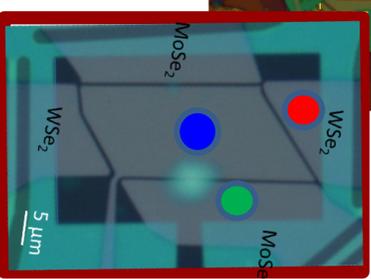
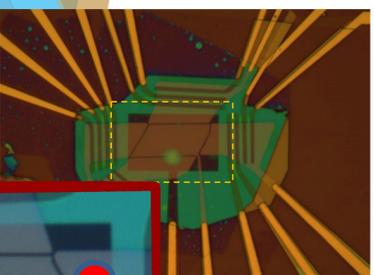
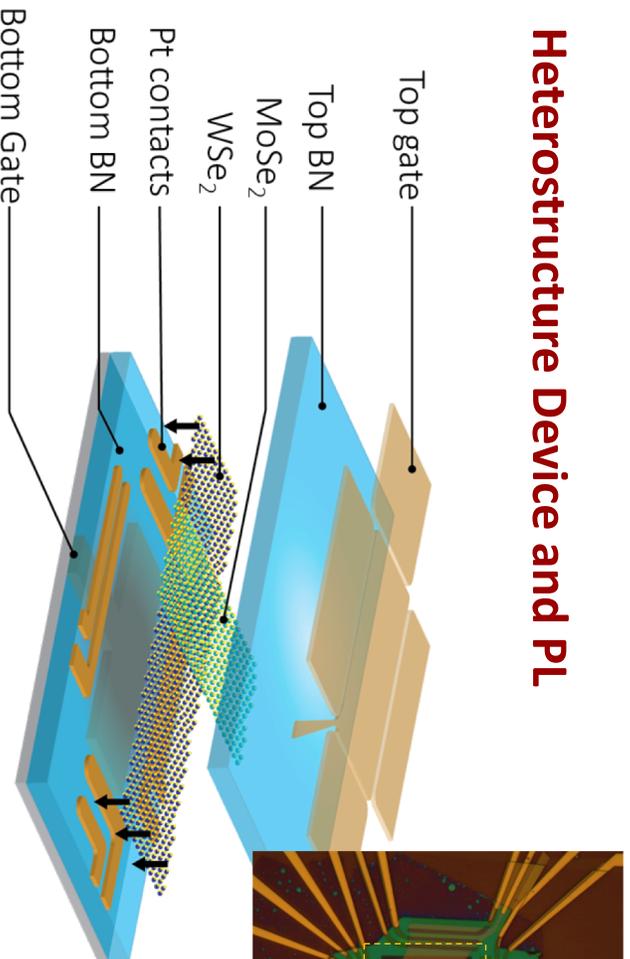
Appl. Phys. Lett. **102**, 012111 (2013)



## • Type II semiconductor heterostructures



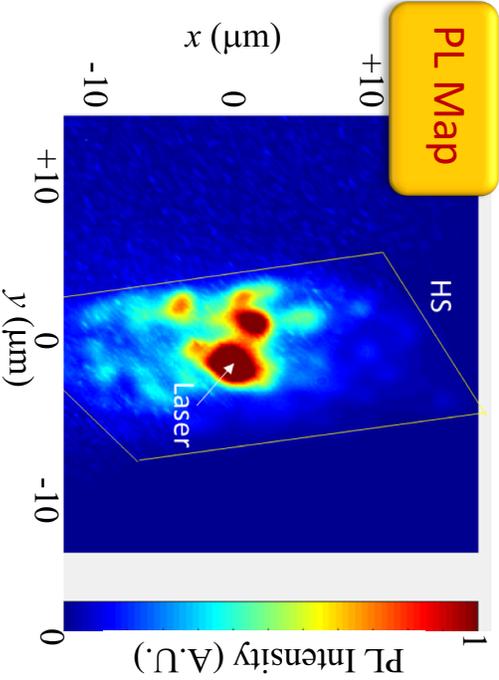
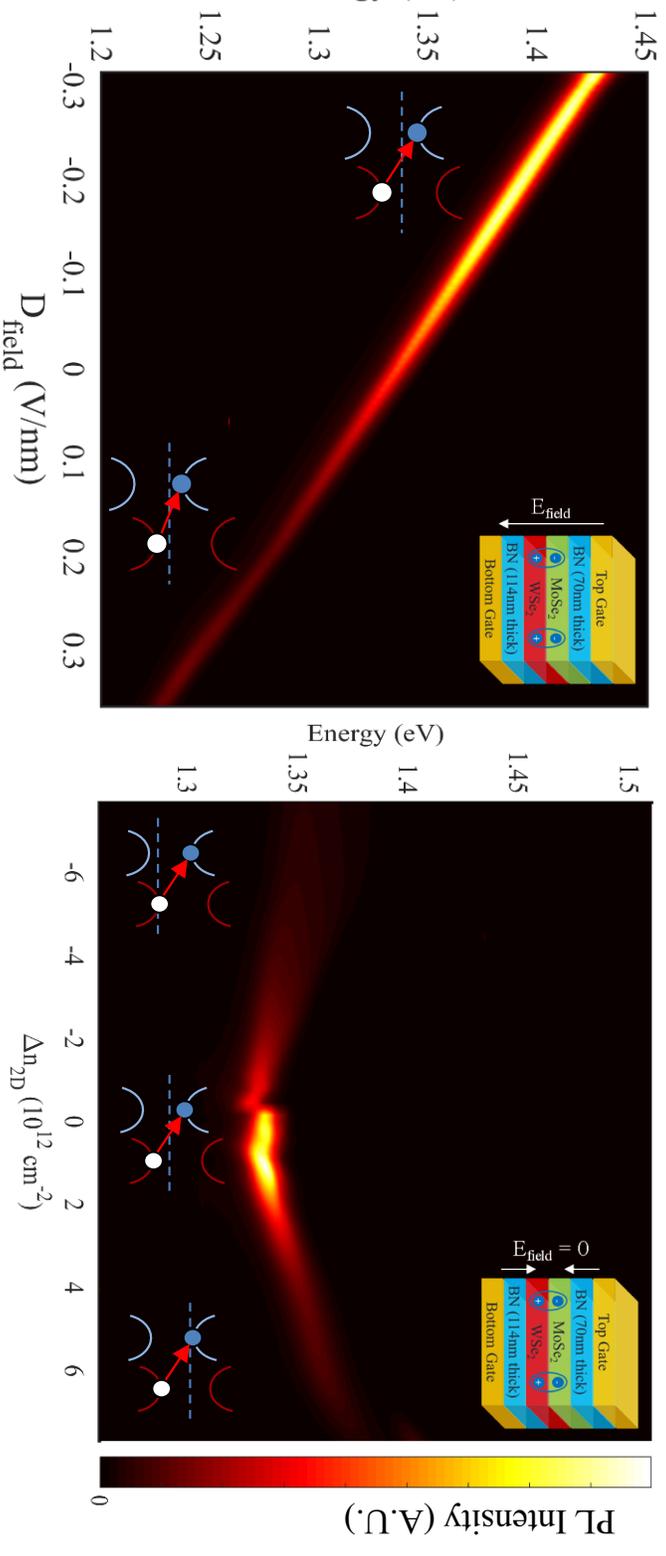
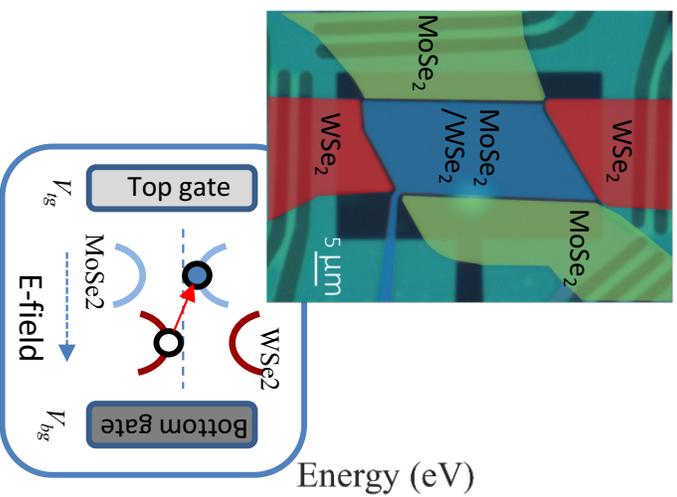
## Heterostructure Device and PL



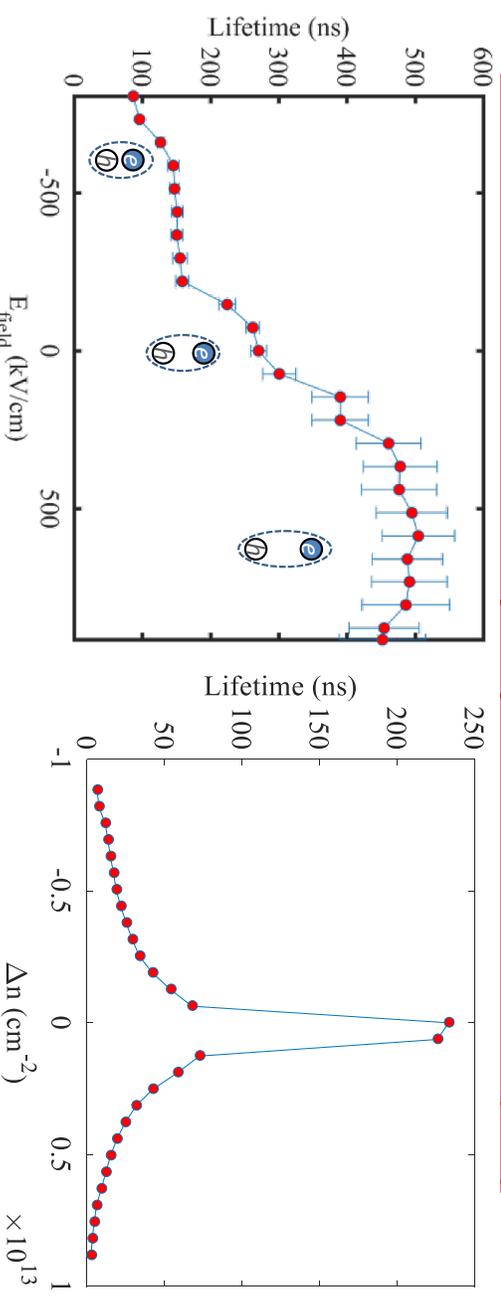
# Tunable Interlayer Excitons in TMDs

MoSe<sub>2</sub>/WSe<sub>2</sub> heterostructure

**Electric Field and Density Dependent Photo Luminescent (4 K)**

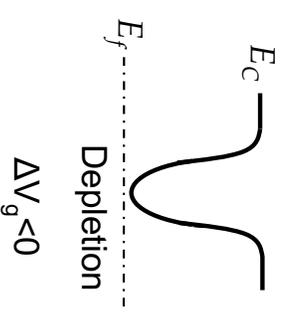
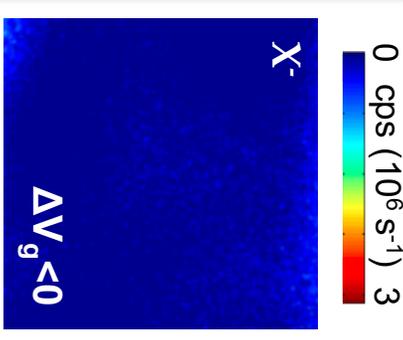
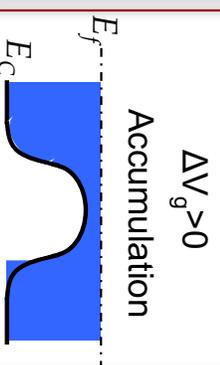
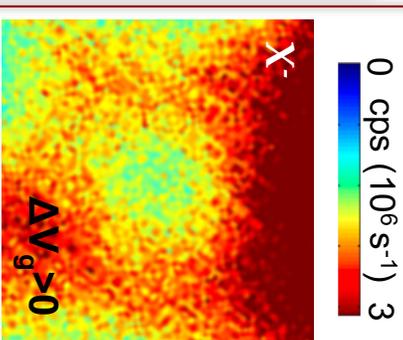
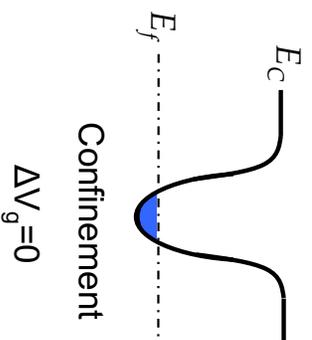
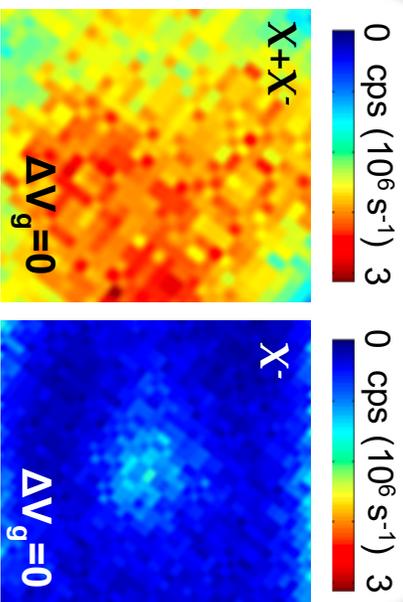
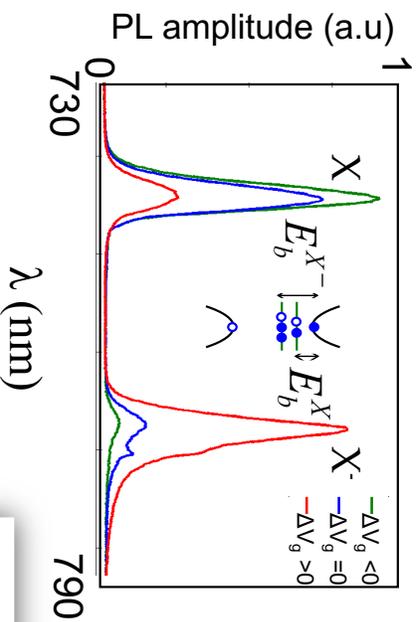
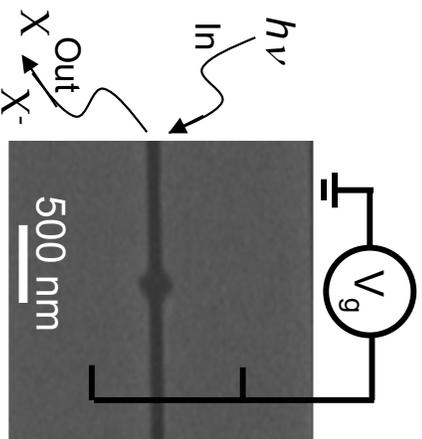


**Electric Field and Density Dependent Life Time (4 K)**

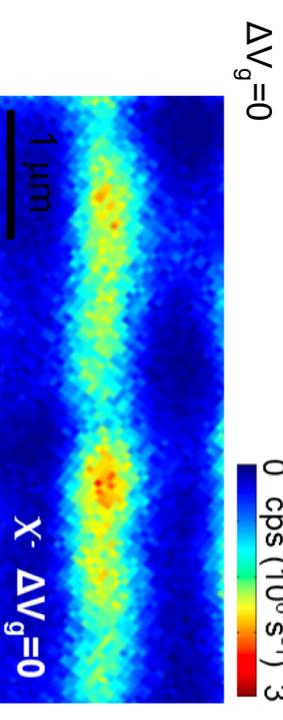
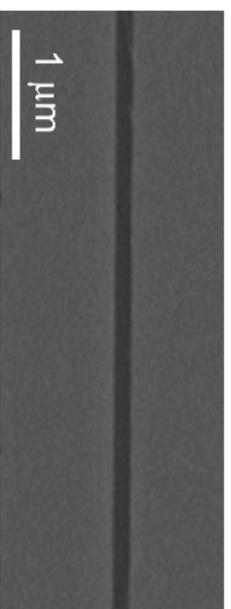


# Gate Controlled Quantum Confined Triions

Local gate with monolayer MoSe<sub>2</sub>



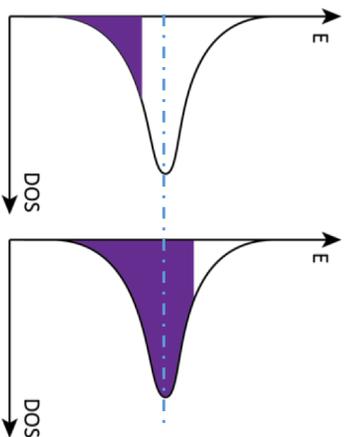
**1D confinement of triions by local gate**



# Exciton condensation between Landau levels

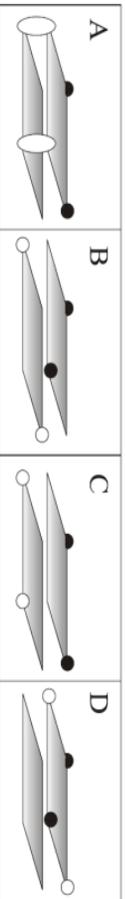
J. P. Eisenstein, Annu. Rev. Condens. Matter Phys. **5**, 159 (2014).

Two partially filled  
Landau levels

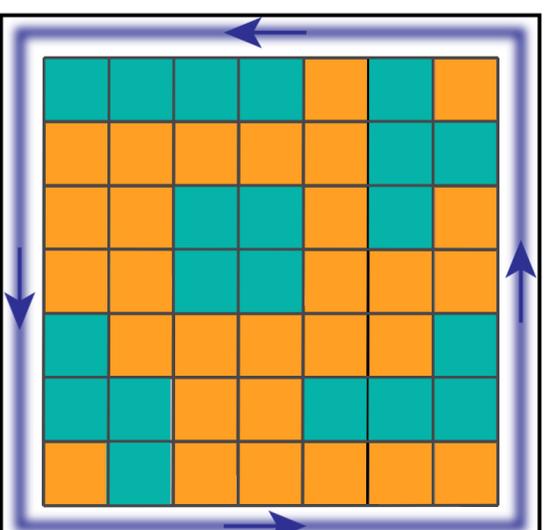


$$|\Psi\rangle = \prod_k \frac{1}{\sqrt{2}} (c_{k,T}^\dagger + e^{i\phi} c_{k,B}^\dagger) |0\rangle$$

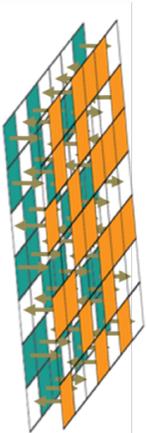
## GaAs Double Quantum Well



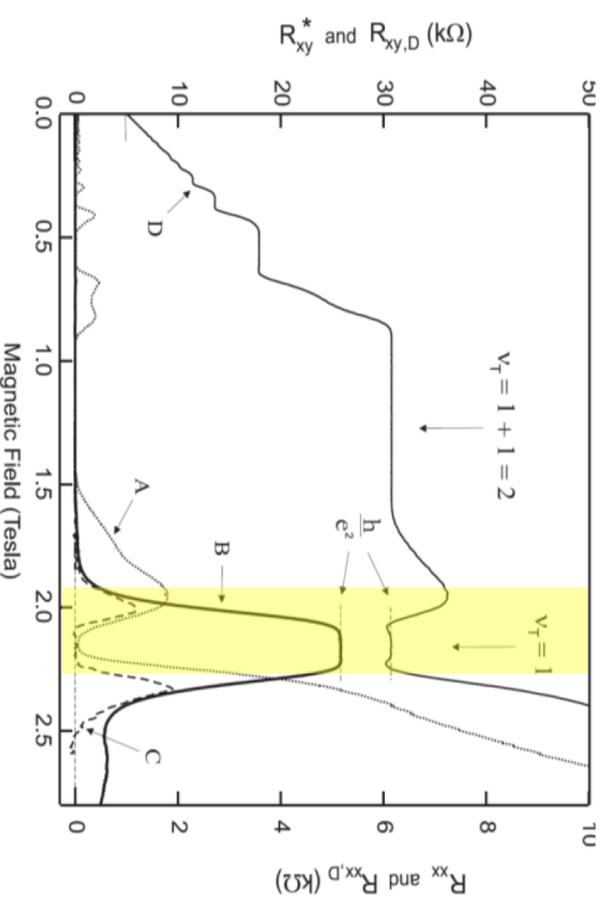
- Quantum Hall effect for two partially filled complementary LLs
- Quantized drag Hall



$B \odot$



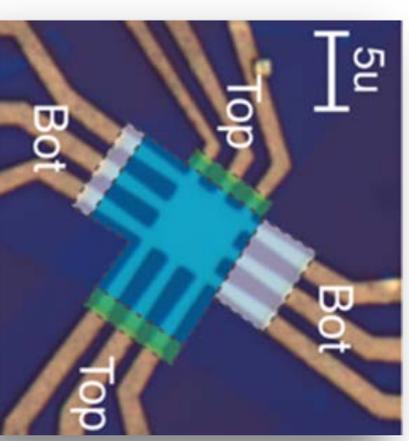
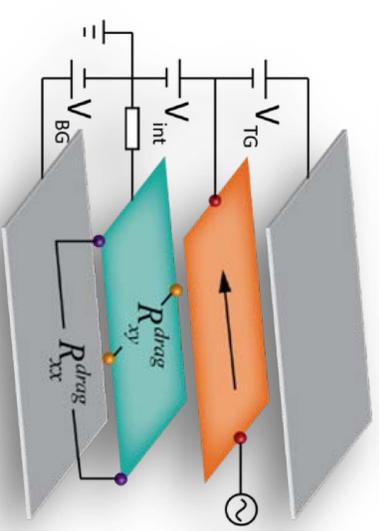
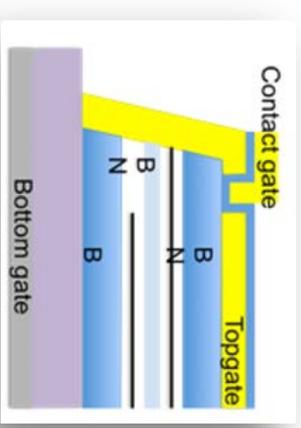
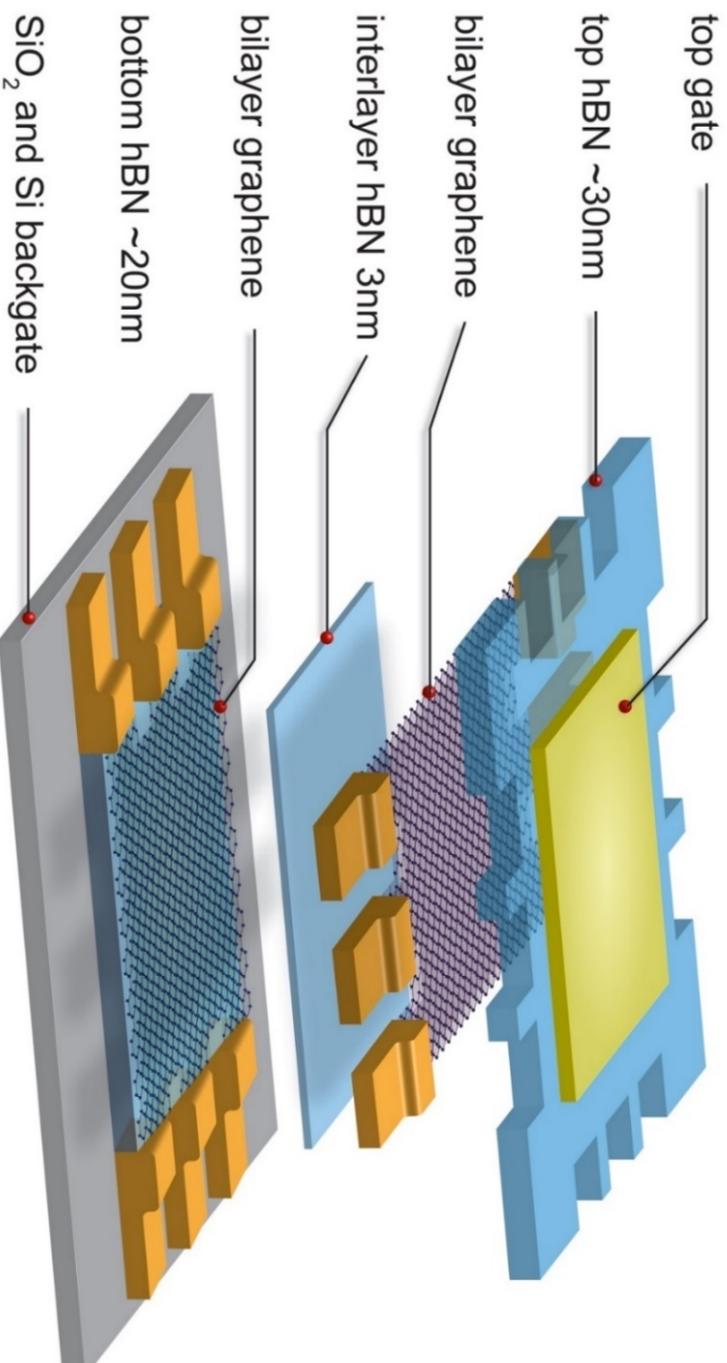
Total Landau level quantum Hall effect



M. Kellogg, et. al, PRL (2002)

# Double Bilayer Graphene Drag Device

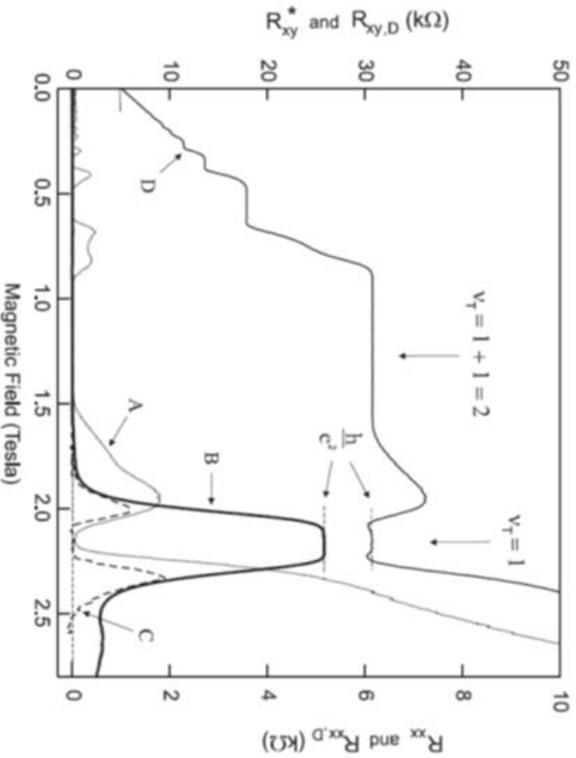
- Mobility  $\sim 10^6$  cm<sup>2</sup>/Vsec
- hBN thickness  $d = 3$  nm
- top and bottom gate
- contact gate
- interlayer bias



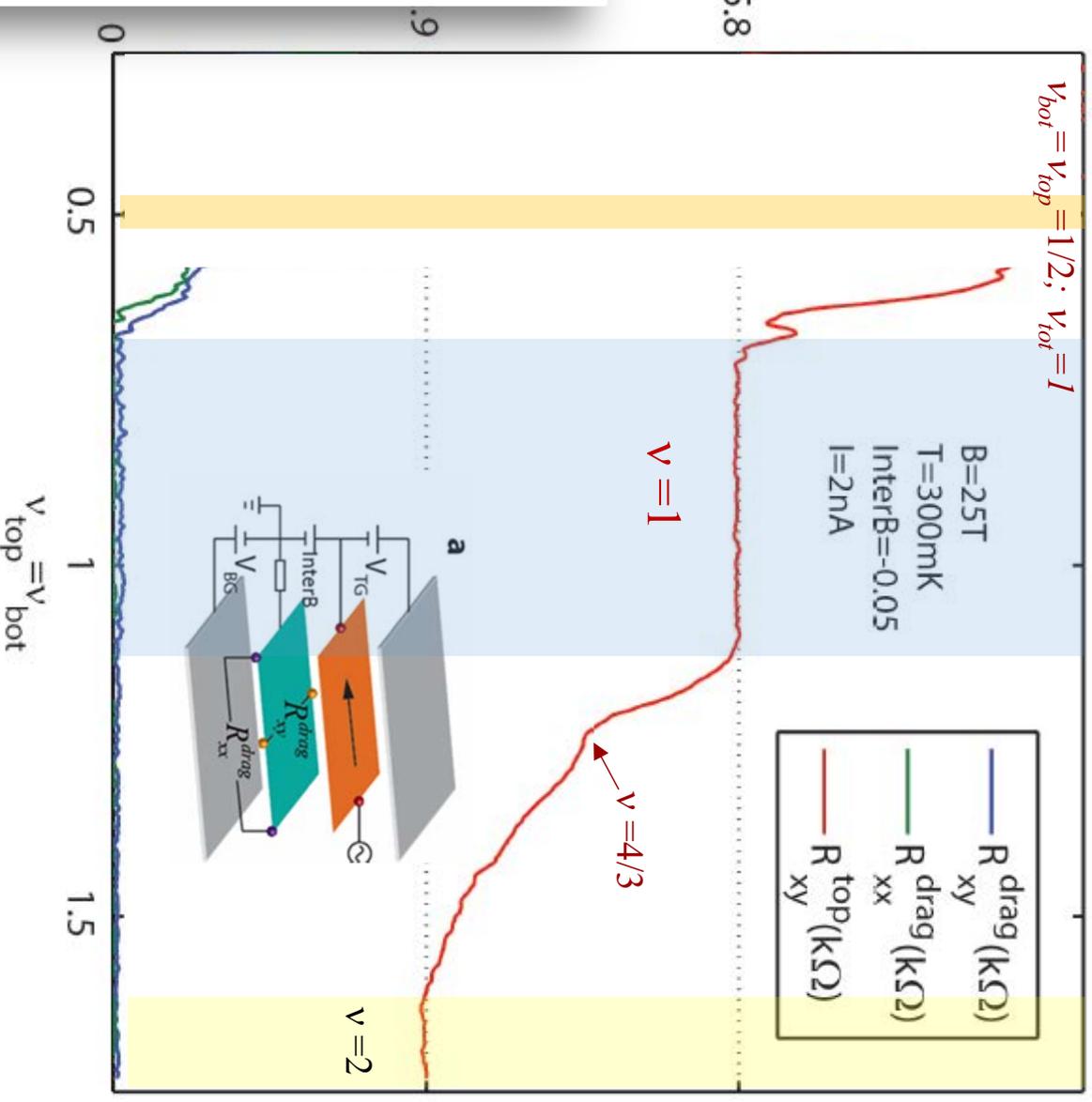
# Bilayer Graphene/hBN/Bilayer Graphene: Quantized Hall Drag

- Mobility  $\sim 10^6$  cm<sup>2</sup>/Vsec
- hBN thickness  $d = 3$  nm
- top and bottom gate
- contact gate
- interlayer bias

## Hall Resistance, Magneto Drag, and Hall Drag

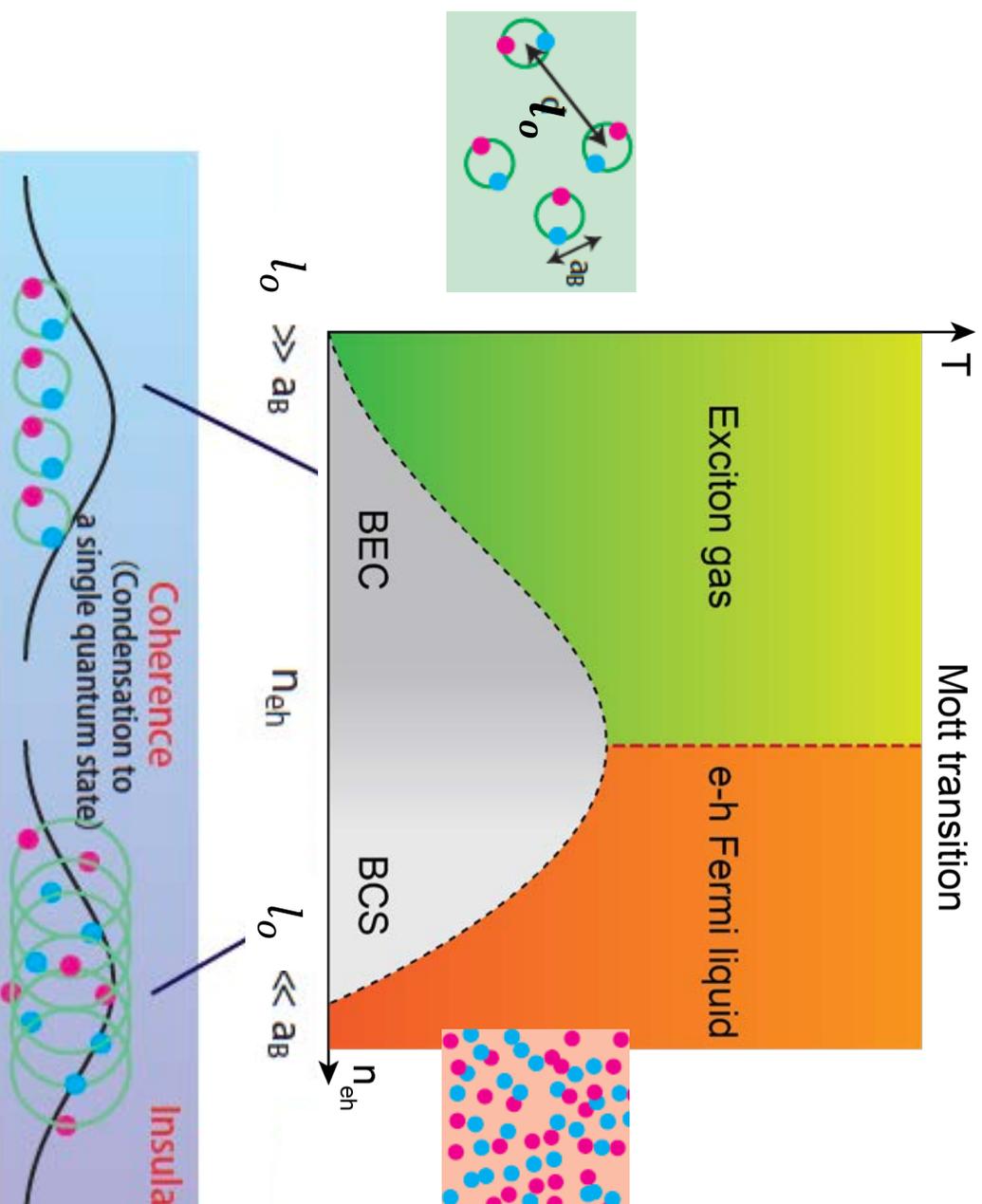


ance (kΩ)  
25.8



# Exciton/e-h Phase Diagram

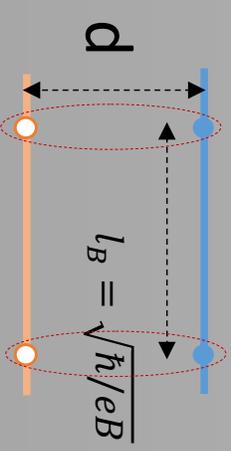
Schematic Meta Stable Phase Diagram of electron-hole in 3D



T. Ogawa and K. Asano (2008)

## Quantum Hall Bilayer:

Competition between inner-layer and interlayer interaction



- $d \ll l_B$ : Halperin (111) state

$$|\Psi\rangle = \prod (z_i - z_j)(w_i - w_j)(z_i - w_j) \times e^{-\frac{1}{4}(\sum |z_i|^2 + \sum |w_i|^2)}$$

- $d \gg l_B$

: weakly coupled composite fermions

$$|\Psi\rangle = P_{LLL} \prod (z_i - z_j)^2 (w_i - w_j)^2 \Psi(k_{F,A}, k_{F,B})$$

- $d \sim l_B$ : many proposals

N. E. Bonesteel, et al., PRL 77, 3009 (1996)

J. Alicea, et al., PRL 103, 256403 (2009).

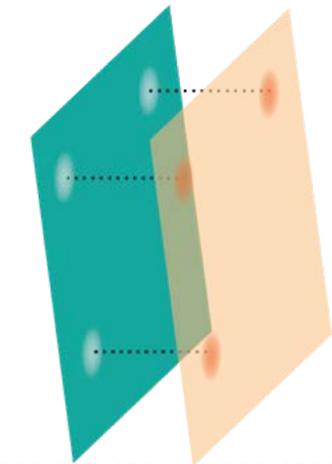
G. Moller, et al., PRB 79, 125106 (2009)

# Potential BCS-BEC Crossover in Magnetoexciton Condensate

Xiaomeng Liu *et al*, unpublished (collaboration with Dean group)

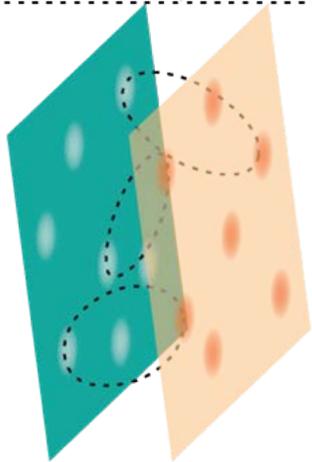
$$d \ll l_B$$

BEC



$$d \gg l_B$$

BCS



- What is the origin of activating behaviors?
- merons/anti-meron activation (??)

- What is the nature of the “BCS” ground state?

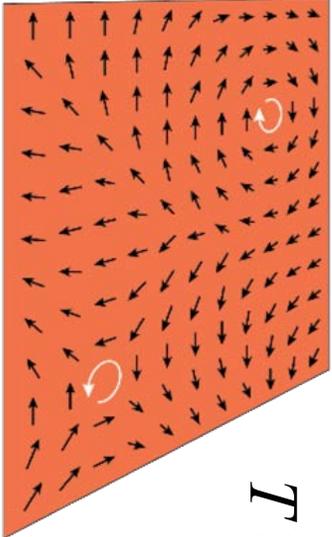
N. E. Bonesteel, et al., PRL 77, 3009 (1996)

J. Alicea, et al., PRL 103, 256403 (2009).

G. Moller, et al., PRB 79, 125106 (2009)

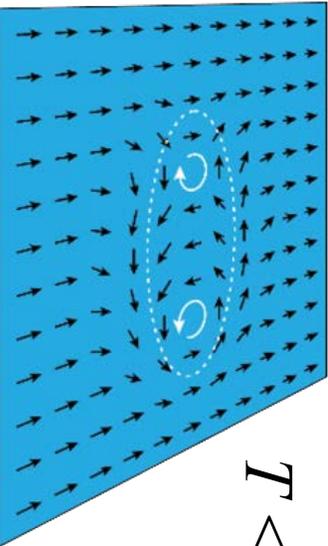
...

Unbound vortices

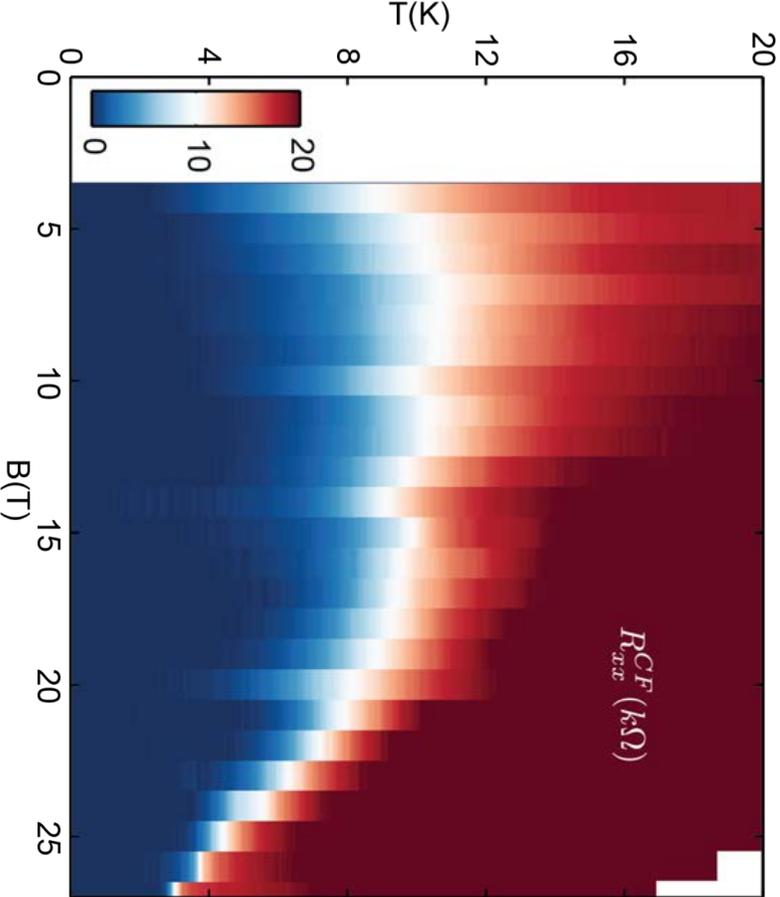


$$T > T_{BKT}$$

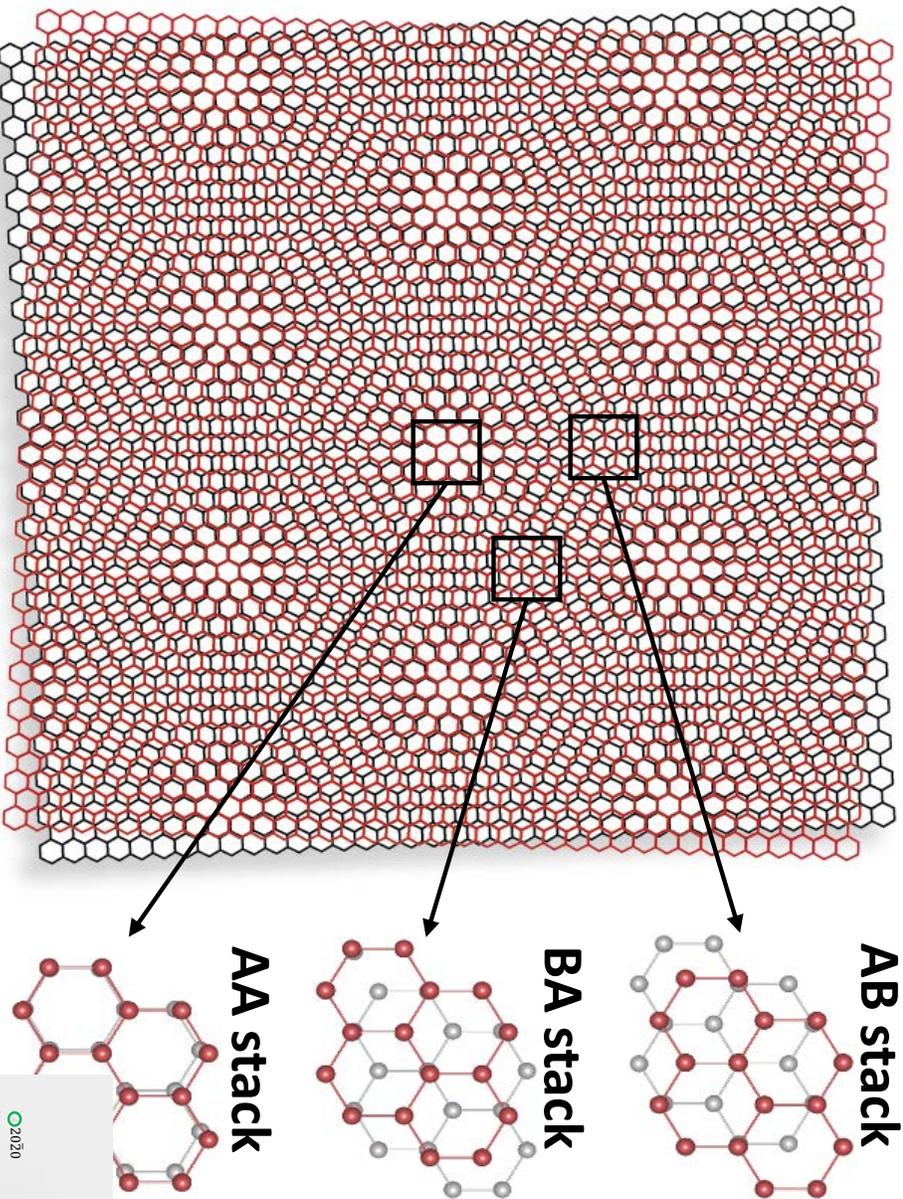
Bound vortex/anti-vortex



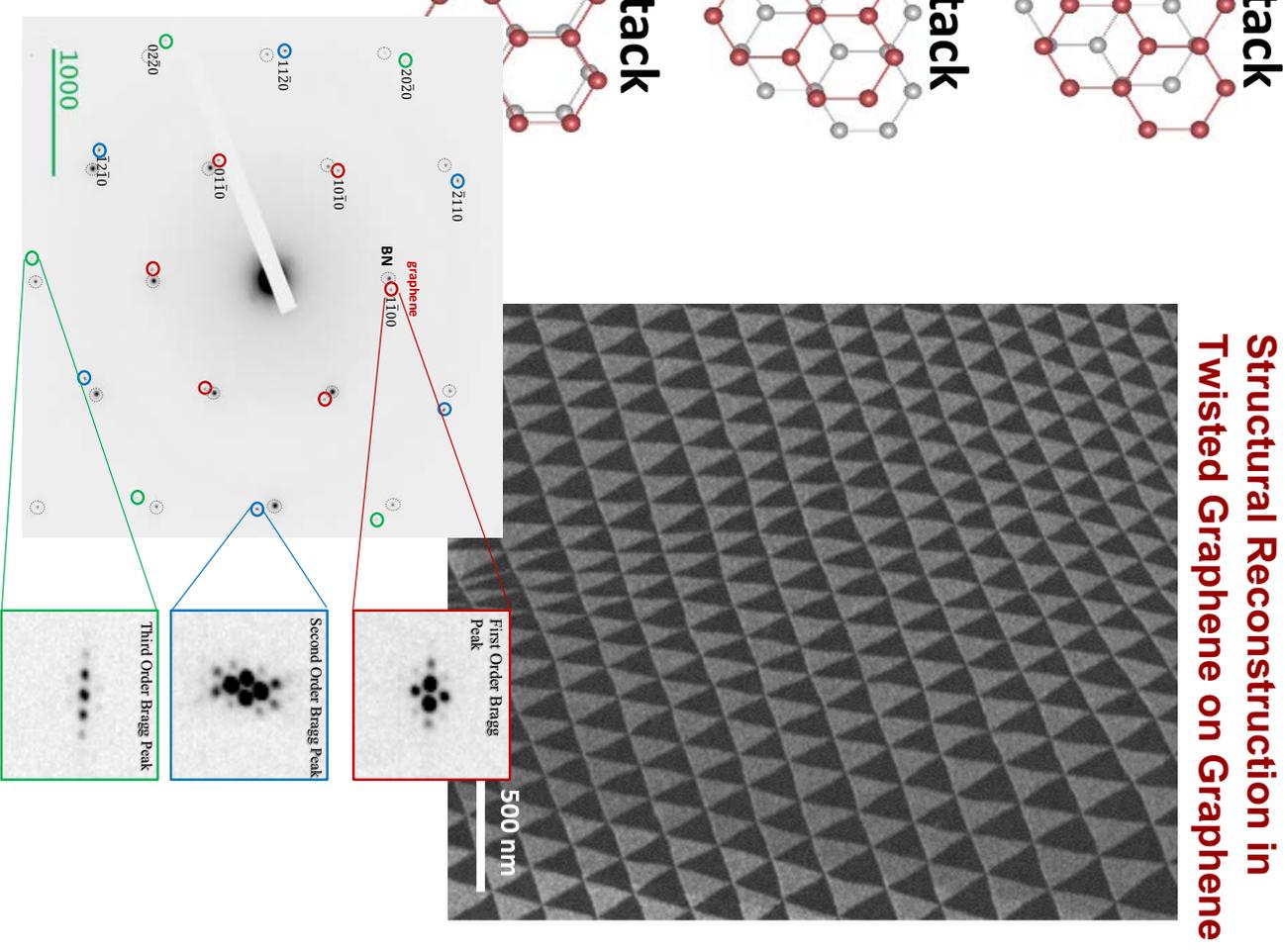
$$T < T_{BKT}$$



# Twisted van der Waals Layer Stack



## Moire Structure in Twisted Graphene on Graphene



# Correlated Quantum State in Twisted Graphene Bilayer

80 | NATURE | VOL 556 | 5 APRIL 2018

## LETTER

doi:10.1038/nature26154

### Correlated insulator behaviour at half-filling in magic-angle graphene superlattices

Yuan Cao<sup>1</sup>, Valla Fatemi<sup>1</sup>, Ahmet Demiri<sup>1</sup>, Shiang Fang<sup>2</sup>, Spencer L. Tomarken<sup>1</sup>, Jason Y. Luo<sup>1</sup>, Javier D. Sanchez-Yamagishi<sup>2</sup>, Kenji Watanabe<sup>3</sup>, Takashi Taniguchi<sup>3</sup>, Efthymios Kaxiras<sup>2,4</sup>, Ray C. Ashoori<sup>1</sup> & Pablo Jarillo-Herrero<sup>1</sup>

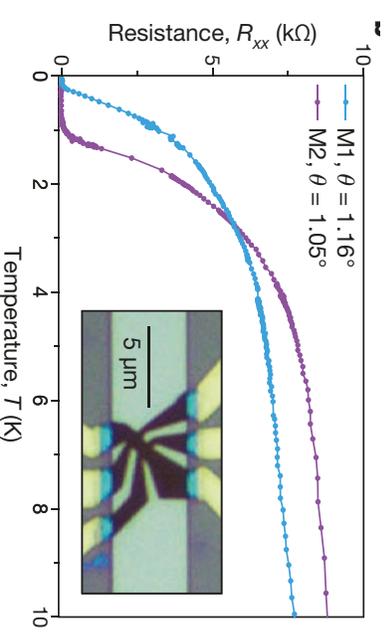
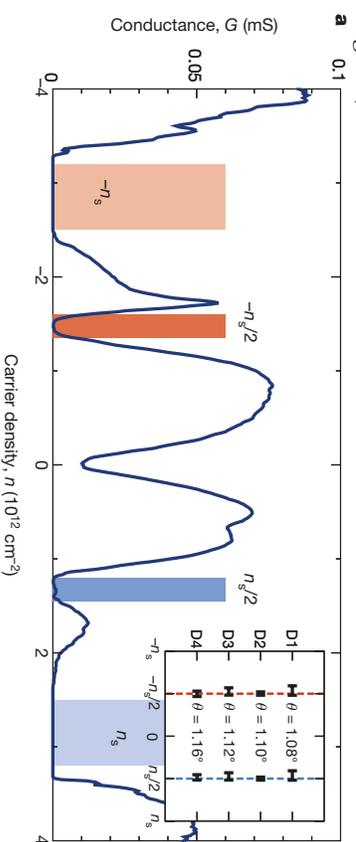
5 APRIL 2018 | VOL 556 | NATURE | 43

## ARTICLE

doi:10.1038/nature26160

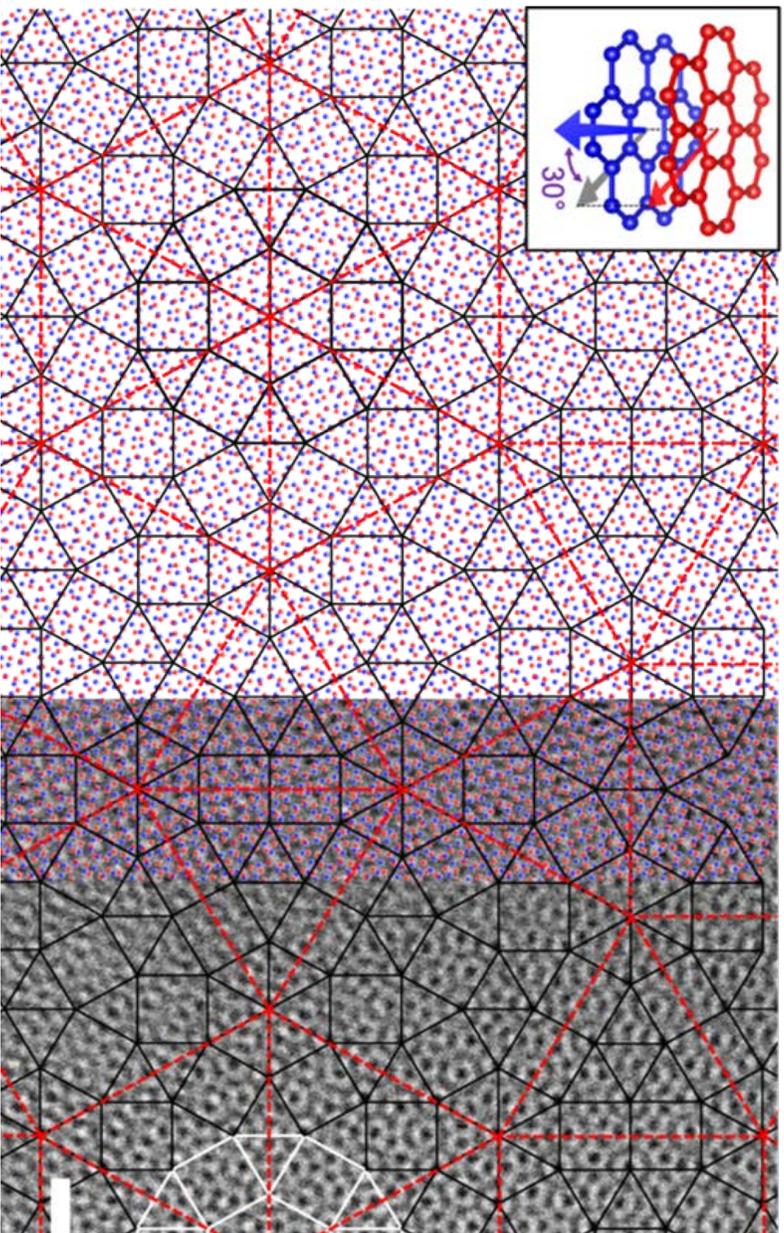
### Unconventional superconductivity in magic-angle graphene superlattices

Yuan Cao<sup>1</sup>, Valla Fatemi<sup>1</sup>, Shiang Fang<sup>2</sup>, Kenji Watanabe<sup>3</sup>, Takashi Taniguchi<sup>3</sup>, Efthymios Kaxiras<sup>2,4</sup> & Pablo Jarillo-Herrero<sup>1</sup>



# Quasi-Crystals in Twisted Graphene

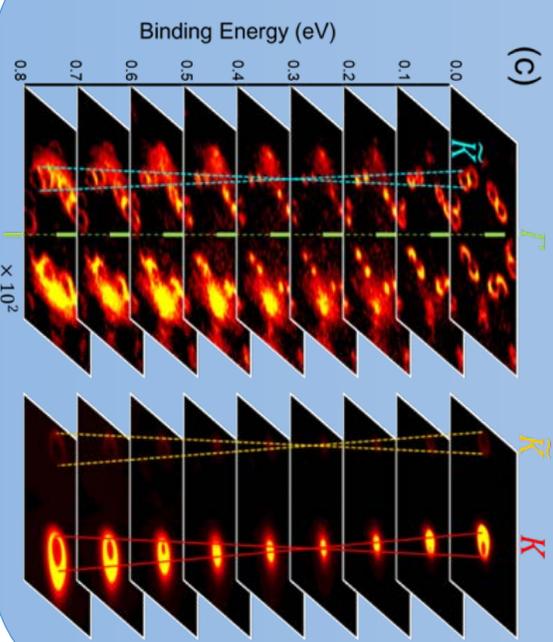
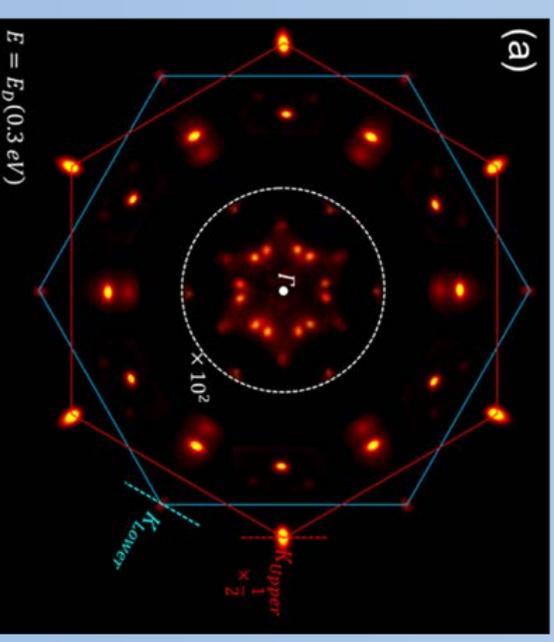
30 degree misaligned bilayer graphene: 12 fold symmetry quasi crystal



S.J. Ahn *et al.*, Science in press (2018)

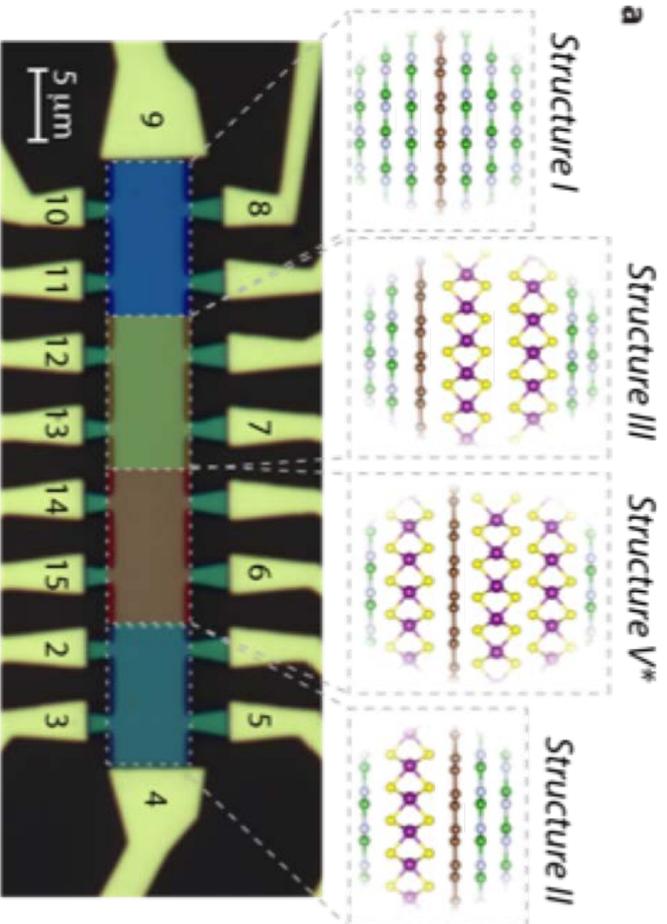
- W2 Wed 5:30; Jounng Real Ahn (experiment)
- W3 Wed 18:15; Pilkyung Moon (theory)

ARPES data on quasicrystals



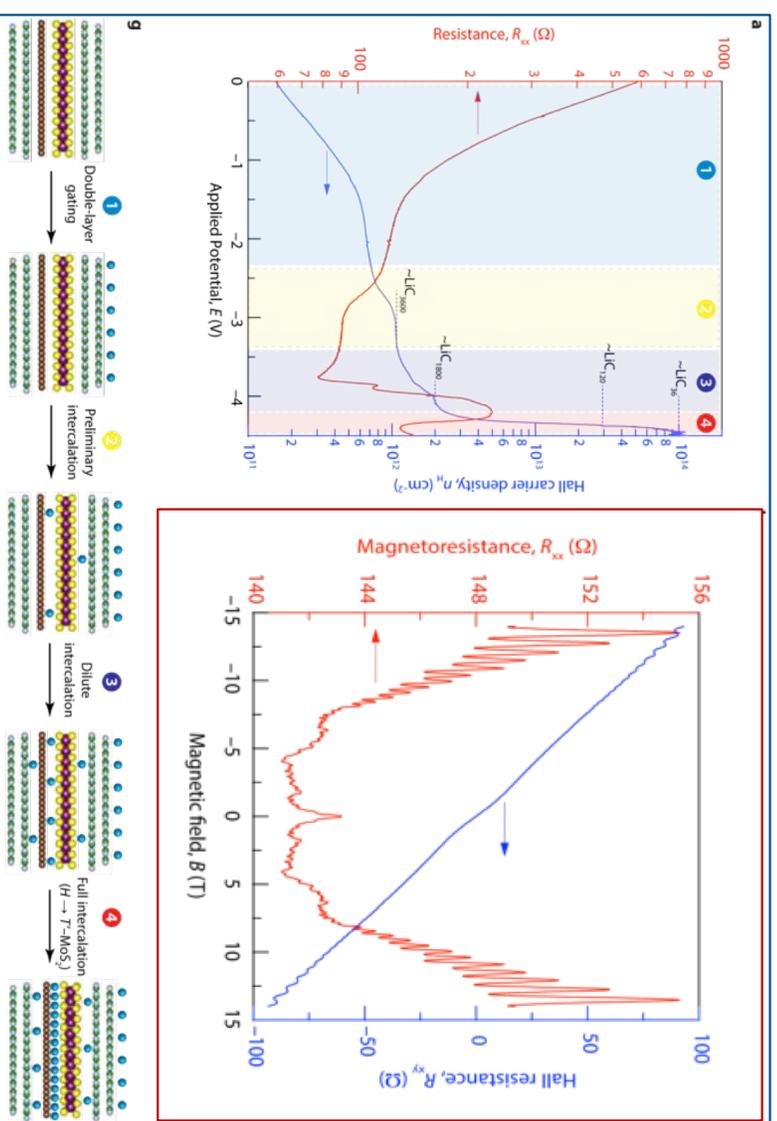
# Intercalation of Graphene/MoS<sub>2</sub> Heterolayer

D. K. Bediako *et al.*, Nature in press (2018)



## Magnetotransport measurement:

- Intermediate intercalation of discrete heterointerfaces
- Charge transfer to individual layers



Electrochemical devices deterministically  
stacked hBN/graphene/MoS<sub>2</sub>

- Next Keynote Speech by J. Smet

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